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(54) **Title:**

CONJUGATED POLYMERS

(57) **Abstract:**

The invention relates to novel polymers containing repeating units based on benzo[1,2-d;4,3-d']bisthiazole, monomers and methods for their preparation, their use as semiconductors in organic electronic (OE) devices, especially in organic photovoltaic (OPV) devices, and to OE and OPV devices comprising these polymers.

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(54) Title: CONJUGATED POLYMERS

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Conjugated Polymers

Field of the Invention

5 The invention relates to novel polymers containing repeating units based on benzo[1,2-*d'*;4,3-*d''*]bisthiazole, monomers and methods for their preparation, their use as semiconductors in organic electronic (OE) devices, especially in organic photovoltaic (OPV) devices, and to OE and
10 OPV devices comprising these polymers.

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Background of the Invention

In recent years there has been growing interest in the use of conjugated, semiconducting polymers for electronic applications. One particular area
15 of importance is organic photovoltaics (OPV). Conjugated polymers have found use in OPVs as they allow devices to be manufactured by solution-processing techniques such as spin casting, dip coating or ink jet printing. Solution processing can be carried out cheaper and on a larger scale compared to the evaporative techniques used to make inorganic thin film
20 devices. Currently, polymer based photovoltaic devices are achieving efficiencies up to 8%.

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The conjugated polymer serves as the main absorber of the solar energy, therefore a low band gap is a basic requirement of the ideal polymer
25 design to absorb the maximum of the solar spectrum.

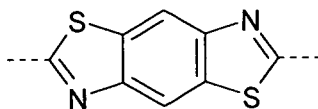
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A commonly used strategy to narrow the band gap of conjugated polymers is to utilize an alternating copolymer consisting of both electron rich donor units and electron deficient acceptor units within the polymer backbone.
30 Additionally, the HOMO and LUMO levels of the polymer should be optimized to maximize the open circuit voltage (V_{oc}).

30

One candidate which has been suggested utilized as donor unit within the polymer backbone is benzo[1,2-*d'*;4,5-*d''*]bisthiazole:
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- 5 Copolymers of benzo[1,2-*d*;4,5-*d'*]bisthiazole and thiophene are described in E. Ahmed, F. S. Kim, H. Xin and S. A. Jenekhe, *Macromolecules* 2009, 42, 8615-8618 and I. Osaka, K. Takimiya and R.D. McCullough, *Adv. Mater.* 2010, published online.
- 10 However, these polymers have limited solubility in commonly used organic solvents, which can inhibit their suitability for device manufacturing methods based on solution processing. In addition, they still do not have satisfying mobility.
- 15 Therefore, there is still a need for organic semiconducting (OSC) materials that are easy to synthesize, especially by methods suitable for mass production, show good structural organization and film-forming properties, exhibit good electronic properties, especially a high charge carrier mobility, good processibility, especially a high solubility in organic solvents, and high stability in air. Especially for use in OPV cells, there is a need for
- 20 OSC materials having a low bandgap, which enable improved light harvesting by the photoactive layer and can lead to higher cell efficiencies, and do not suffer from open circuit potentials (V_{oc}) in OPV bulk-hetero-junction devices, or do so to a lower extent than polymers from prior art.
- 25 It was an aim of the present invention to provide compounds for use as organic semiconducting materials that do not have the drawbacks of prior art materials as described above, are easy to synthesize, especially by methods suitable for mass production, and do especially show good
- 30 processibility, high stability, good solubility in organic solvents, high charge carrier mobility, and a low bandgap. Another aim of the invention was to extend the pool of OSC materials available to the expert. Other aims of the present invention are immediately evident to the expert from the following detailed description.
- 35 The inventors of the present invention have found that these aims can be

achieved by providing conjugated polymers comprising repeating units that contain a benzo[1,2-*d*;4,3-*d'*]bisthiazole moiety.

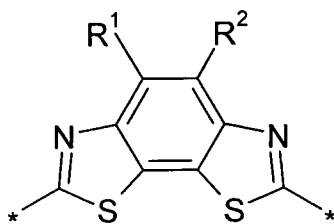
5 It was found that conjugated polymers based on this unit show good processability and high solubility in organic solvents, and are thus especially suitable for large scale production using solution processing methods. At the same time, they show a low bandgap, high charge carrier mobility and high oxidative stability and are promising materials for organic electronic OE devices, especially for OPV devices.

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Summary of the Invention

The invention relates to a conjugated polymer comprising one or more identical or different repeating units containing a moiety of formula I:

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wherein an asterisk indicates a link to a neighbored group, and R¹ and R² are, each independently of one another, H, halogen, or an optionally substituted carbonyl or hydrocarbonyl group.

25

The invention further relates to a conjugated polymer comprising one or more repeating units which contain a moiety of formula I and/or contain one or more units (hereinafter also referred to as Ar¹, Ar² and Ar³) selected from aryl and heteroaryl units that are optionally substituted, and wherein at least one of the repeating units in the polymer contains at least one moiety of formula I.

30

Preferably, R¹ and R² in formula I are selected from H, straight-chain, branched or cyclic alkyl with 1 to 35 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -C(O)-, -C(O)-O-, -O-C(O)-, -O-C(O)-O-, -CR⁰=CR⁰⁰- or -C≡C- and in which one or more H

35

atoms are optionally replaced by F, Cl, Br, I or CN, or denote aryl, heteroaryl, aryloxy, heteroaryloxy, arylcarbonyl, heteroarylcarbonyl, arylcarbonyloxy, heteroarylcarbonyloxy, aryloxy carbonyl or heteroaryloxy carbonyl having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R^3 , wherein

5 R^0 and R^{00} are independently of each other H or optionally substituted C_{1-40} carbonyl or hydrocarbonyl,

10 R^3 is on each occurrence identically or differently F, Br, Cl, -CN, -NC, -NCO, -NCS, -OCN, -SCN, $-C(O)NR^0R^{00}$, $-C(O)X^0$, $-C(O)R^0$, $-NH_2$, $-NR^0R^{00}$, -SH, $-SR^0$, $-SO_3H$, $-SO_2R^0$, -OH, $-NO_2$, $-CF_3$, $-SF_5$, optionally substituted silyl, carbonyl or hydrocarbonyl with 1 to 40 C atoms that is optionally substituted and optionally comprises one or more hetero atoms, or P-Sp-,

15 P is a polymerisable or crosslinkable group,

20 Sp is a spacer group or a single bond, and

X^0 is halogen.

25 The conjugated polymers according to the present invention are preferably selected of formula II:



wherein

30 U is on each occurrence identically or differently a moiety of formula I as described above and below,

35 Ar^1 , Ar^2 , Ar^3 are, on each occurrence identically or differently, and independently of each other, aryl or heteroaryl that is optionally substituted, preferably by one or more groups R^3

as defined above, and one or both of Ar¹ and Ar² may also denote a single bond,

- 5 Y¹ and Y² are independently of each other H, F, Cl or CN,
- x is on each occurrence identically or differently 0, 1 or 2, wherein in at least one repeating unit, i.e. in at least one unit $-(\text{Ar}^1\text{-U-Ar}^2)_x\text{-(Ar}^3)_y\text{-}$, x is 1,
- 10 y is on each occurrence identically or differently 0, 1 or 2,
- n is an integer > 1.

15 The invention further relates to monomers containing a moiety of formula I, which are suitable for the preparation of conjugated polymers as described above and below.

20 The invention further relates to a mixture or blend comprising one or more polymers according to the present invention and one or more additional compounds or polymers which are preferably selected from compounds and polymers having one or more of semiconducting, charge transport, hole or electron transport, hole or electron blocking, electrically conducting, photoconducting or light emitting properties.

25 The invention further relates to a formulation comprising one or more polymers, mixtures or or blends according to the present invention and optionally one or more solvents, preferably selected from organic solvents.

30 The invention further relates to the use of polymers, mixtures, blends and formulations according to the present invention as charge transport, semiconducting, electrically conducting, photoconducting or light emitting material in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices.

35 The invention further relates to a charge transport, semiconducting, electrically conducting, photoconducting or light emitting material or

component comprising one or more polymers, polymer blends of formulations according to the present invention.

5 The invention further relates to an optical, electrooptical or electronic component or device comprising one or more polymers, polymer blends, formulations, components or materials according to the present invention.

10 The optical, electrooptical, electronic electroluminescent and photoluminescent components or devices include, without limitation, organic field effect transistors (OFET), thin film transistors (TFT), integrated circuits (IC), logic circuits, capacitors, radio frequency identification (RFID) tags, devices or components, organic light emitting diodes (OLED), organic light emitting transistors (OLET), flat panel displays, backlights of displays, organic photovoltaic devices (OPV), solar cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, 15 sensor devices, charge injection layers, charge transport layers or interlayers in polymer light emitting diodes (PLEDs), organic plasmon-emitting diodes (OPEDs), Schottky diodes, planarising layers, antistatic films, polymer electrolyte membranes (PEM), conducting substrates, 20 conducting patterns, electrode materials in batteries, alignment layers, biosensors, biochips, security markings, security devices, and components or devices for detecting and discriminating DNA sequences.

25 Detailed Description of the Invention

The monomers and polymers of the present invention are easy to synthesize and exhibit several advantageous properties, like a low bandgap, a high charge carrier mobility, a high solubility in organic solvents, a good processability for the device manufacture process, a high 30 oxidative stability and a long lifetime in electronic devices.

In addition, they show the following advantageous properties:

35 i) Additional solubility can be introduced into the polymer by inclusion of one or two solubilising groups (R^1 and R^2 in formula I), or by inclusion of

co-monomers containing multiple solubilising groups.

5 ii) The presence of two nitrogen atoms within the monomer unit results in modified electronic energies (HOMO/LUMO levels) of the polymer, particularly in a deepening of the HOMO level in order to achieve a higher open circuit potential (V_{oc}) in an OPV bulk-heterojunction. Increasing the V_{oc} in a device is one method of increasing device efficiency. Additionally, polymers that exhibit deeper HOMO levels will be more oxidatively stable to ambient conditions *i.e.* the presence of moisture and oxygen as explained in D. M. de Leeuw, M. M. J. Simenon, A. R. Brown, R. E. F. Einerhand, Synth. Met., 1997, 87, 53.

10 iii) The solubilising groups are introduced into the monomer unit in the penultimate step of the synthetic route, thereby allowing facile modification and optimisation of the groups.

15 iv) The solubilising groups are in plane with the aromatic polymer backbone, allowing more effective inter-chain π - π stacking, which will give improved charge transport properties.

20 v) Additional fine-tuning of the electronic energies (HOMO/LUMO levels) by further modification of the benzo[1,2-*b*;4,5-*b'*]dithiophene core or co-polymerisation with appropriate co-monomer(s) can afford candidate materials for organic photovoltaic applications.

25 Above and below, the term "polymer" generally means a molecule of high relative molecular mass, the structure of which essentially comprises the multiple repetition of units derived, actually or conceptually, from molecules of low relative molecular mass (PAC, 1996, 68, 2291). The term "oligomer" generally means a molecule of intermediate relative molecular mass, the structure of which essentially comprises a small plurality of units derived, actually or conceptually, from molecules of lower relative molecular mass (PAC, 1996, 68, 2291). In a preferred sense according to the present invention a polymer means a compound having > 1, preferably ≥ 5 repeating units, and an oligomer means a compound with > 1 and < 10, preferably < 5, repeating units.

Above and below, in a formula showing a polymer or a repeating unit, like formula I and its subformulae, an asterisk ("*") denotes a linkage to the adjacent repeating unit in the polymer chain.

5

The terms "repeating unit" and "monomeric unit" mean the constitutional repeating unit (CRU), which is the smallest constitutional unit the repetition of which constitutes a regular macromolecule, a regular oligomer molecule, a regular block or a regular chain (PAC, 1996, 68, 2291).

10

The term "leaving group" means an atom or group (charged or uncharged) that becomes detached from an atom in what is considered to be the residual or main part of the molecule taking part in a specified reaction (see also PAC, 1994, 66, 1134).

15

The term "conjugated" means a compound containing mainly C atoms with sp^2 -hybridisation (or optionally also sp -hybridisation), which may also be replaced by hetero atoms. In the simplest case this is for example a compound with alternating C-C single and double (or triple) bonds, but does also include compounds with units like 1,3-phenylene. "Mainly" means in this connection that a compound with naturally (spontaneously) occurring defects, which may lead to interruption of the conjugation, is still regarded as a conjugated compound.

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Unless stated otherwise, the molecular weight is given as the number average molecular weight M_n or weight average molecular weight M_w , which is determined by gel permeation chromatography (GPC) against polystyrene standards in eluent solvents such as tetrahydrofuran, trichloromethane (TCM, chloroform), chlorobenzene or 1,2,4-trichlorobenzene. Unless stated otherwise, trichloromethane is used as solvent.

30

The degree of polymerization (n) means the number average degree of polymerization given as $n = M_n/M_U$, wherein M_U is the molecular weight of the single repeating unit as described in J. M. G. Cowie, *Polymers: Chemistry & Physics of Modern Materials*, Blackie, Glasgow, 1991.

35

The term "carbonyl group" as used above and below denotes any

monovalent or multivalent organic radical moiety which comprises at least one carbon atom either without any non-carbon atoms (like for example $-C\equiv C-$), or optionally combined with at least one non-carbon atom such as N, O, S, P, Si, Se, As, Te or Ge (for example carbonyl etc.). The term "hydrocarbyl group" denotes a carbyl group that does additionally contain one or more H atoms and optionally contains one or more hetero atoms like for example N, O, S, P, Si, Se, As, Te or Ge.

A carbyl or hydrocarbyl group comprising a chain of 3 or more C atoms may also be straight-chain, branched and/or cyclic, including spiro and/or fused rings.

Preferred carbyl and hydrocarbyl groups include alkyl, alkoxy, alkylcarbonyl, alkoxy carbonyl, alkylcarbonyloxy and alkoxy carbonyloxy, each of which is optionally substituted and has 1 to 40, preferably 1 to 25, very preferably 1 to 18 C atoms, furthermore optionally substituted aryl or aryloxy having 6 to 40, preferably 6 to 25 C atoms, furthermore alkylaryloxy, arylcarbonyl, aryloxy carbonyl, arylcarbonyloxy and aryloxy carbonyloxy, each of which is optionally substituted and has 6 to 40, preferably 7 to 40 C atoms, wherein all these groups do optionally contain one or more hetero atoms, preferably selected from N, O, S, P, Si, Se, As, Te and Ge.

The carbyl or hydrocarbyl group may be a saturated or unsaturated acyclic group, or a saturated or unsaturated cyclic group. Unsaturated acyclic or cyclic groups are preferred, especially aryl, alkenyl and alkynyl groups (especially ethynyl). Where the C_1-C_{40} carbyl or hydrocarbyl group is acyclic, the group may be straight-chain or branched. The C_1-C_{40} carbyl or hydrocarbyl group includes for example: a C_1-C_{40} alkyl group, a C_1-C_{40} alkoxy or oxaalkyl group, a C_2-C_{40} alkenyl group, a C_2-C_{40} alkynyl group, a C_3-C_{40} allyl group, a C_4-C_{40} alkyldienyl group, a C_4-C_{40} polyenyl group, a C_6-C_{18} aryl group, a C_6-C_{40} alkylaryl group, a C_6-C_{40} arylalkyl group, a C_4-C_{40} cycloalkyl group, a C_4-C_{40} cycloalkenyl group, and the like. Preferred among the foregoing groups are a C_1-C_{20} alkyl group, a C_2-C_{20} alkenyl group, a C_2-C_{20} alkynyl group, a C_3-C_{20} allyl group, a C_4-C_{20} alkyldienyl group, a C_6-C_{12} aryl group, and a C_4-C_{20} polyenyl group, respectively. Also

included are combinations of groups having carbon atoms and groups having hetero atoms, like e.g. an alkynyl group, preferably ethynyl, that is substituted with a silyl group, preferably a trialkylsilyl group.

- 5 Aryl and heteroaryl preferably denote a mono-, bi- or tricyclic aromatic or heteroaromatic group with 4 to 30 ring C atoms that may also comprise condensed rings and is optionally substituted with one or more groups L, wherein L is selected from halogen, -CN, -NC, -NCO, -NCS, -OCN, -SCN, -C(=O)NR⁰R⁰⁰, -C(=O)X⁰, -C(=O)R⁰, -NH₂, -NR⁰R⁰⁰, -SH, -SR⁰, -SO₃H, -SO₂R⁰, -OH, -NO₂, -CF₃, -SF₅, optionally substituted silyl, carbyl or hydrocarbyl with 1 to 40 C atoms that is optionally substituted and optionally comprises one or more hetero atoms, or P-Sp, with R⁰, R⁰⁰, X⁰, P and Sp having the meanings given above and below.
- 10
- 15 Very preferred substituents L are selected from halogen, most preferably F, or alkyl, alkoxy, oxaalkyl, thioalkyl, fluoroalkyl and fluoroalkoxy with 1 to 12 C atoms or alkenyl, alkynyl with 2 to 12 C atoms.
- 20 Especially preferred aryl and heteroaryl groups are phenyl in which, in addition, one or more CH groups may be replaced by N, naphthalene, thiophene, selenophene, thienothiophene, dithienothiophene, fluorene and oxazole, all of which can be unsubstituted, mono- or polysubstituted with L as defined above. Very preferred rings are selected from pyrrole, preferably N-pyrrole, pyridine, preferably 2- or 3-pyridine, pyrimidine, thiophene preferably 2-thiophene, selenophene, preferably 2-selenophene, thieno[3,2-b]thiophene, thiazole, thiadiazole, oxazole and oxadiazole, especially preferably thiophene-2-yl, 5-substituted thiophene-2-yl or pyridine-3-yl, all of which can be unsubstituted, mono- or polysubstituted with L as defined above.
- 25
- 30
- 35 An alkyl or alkoxy radical, i.e. where the terminal CH₂ group is replaced by -O-, can be straight-chain or branched. It is preferably straight-chain, has 2, 3, 4, 5, 6, 7 or 8 carbon atoms and accordingly is preferably ethyl, propyl, butyl, pentyl, hexyl, heptyl, octyl, ethoxy, propoxy, butoxy, pentoxy, hexoxy, heptoxy, or octoxy, furthermore methyl, nonyl, decyl, undecyl,

dodecyl, tridecyl, tetradecyl, pentadecyl, nonoxy, decoxy, undecoxy, dodecoxy, tridecoxy or tetradecoxy, for example.

5 An alkenyl group, wherein one or more CH₂ groups are replaced by -CH=CH- can be straight-chain or branched. It is preferably straight-chain, has 2 to 10 C atoms and accordingly is preferably vinyl, prop-1-, or prop-2-enyl, but-1-, 2- or but-3-enyl, pent-1-, 2-, 3- or pent-4-enyl, hex-1-, 2-, 3-, 4- or hex-5-enyl, hept-1-, 2-, 3-, 4-, 5- or hept-6-enyl, oct-1-, 2-, 3-, 4-, 5-, 6- or oct-7-enyl, non-1-, 2-, 3-, 4-, 5-, 6-, 7- or non-8-enyl, dec-1-, 2-, 3-, 4-, 5-, 6-, 7-, 8- or dec-9-enyl.

15 Especially preferred alkenyl groups are C₂-C₇-1E-alkenyl, C₄-C₇-3E-alkenyl, C₅-C₇-4-alkenyl, C₆-C₇-5-alkenyl and C₇-6-alkenyl, in particular C₂-C₇-1E-alkenyl, C₄-C₇-3E-alkenyl and C₅-C₇-4-alkenyl. Examples for particularly preferred alkenyl groups are vinyl, 1E-propenyl, 1E-butenyl, 1E-pentenyl, 1E-hexenyl, 1E-heptenyl, 3-butenyl, 3E-pentenyl, 3E-hexenyl, 3E-heptenyl, 4-pentenyl, 4Z-hexenyl, 4E-hexenyl, 4Z-heptenyl, 5-hexenyl, 6-heptenyl and the like. Groups having up to 5 C atoms are generally preferred.

20 An oxaalkyl group, i.e. where one CH₂ group is replaced by -O-, is preferably straight-chain 2-oxapropyl (=methoxymethyl), 2-(=ethoxymethyl) or 3-oxabutyl (=2-methoxyethyl), 2-, 3-, or 4-oxapentyl, 2-, 3-, 4-, or 5-oxahexyl, 2-, 3-, 4-, 5-, or 6-oxaheptyl, 2-, 3-, 4-, 5-, 6- or 7-oxaoctyl, 2-, 3-, 4-, 5-, 6-, 7- or 8-oxanonyl or 2-, 3-, 4-, 5-, 6-, 7-, 8- or 9-oxadecyl, for example. Oxaalkyl, i.e. where one CH₂ group is replaced by -O-, is preferably straight-chain 2-oxapropyl (=methoxymethyl), 2-(=ethoxymethyl) or 3-oxabutyl (=2-methoxyethyl), 2-, 3-, or 4-oxapentyl, 2-, 3-, 4-, or 5-oxahexyl, 2-, 3-, 4-, 5-, or 6-oxaheptyl, 2-, 3-, 4-, 5-, 6- or 7-oxaoctyl, 2-, 3-, 4-, 5-, 6-, 7- or 8-oxanonyl or 2-, 3-, 4-, 5-, 6-, 7-, 8- or 9-oxadecyl, for example.

35 In an alkyl group wherein one CH₂ group is replaced by -O- and one by -C(O)-, these radicals are preferably neighbored. Accordingly these radicals together form a carbonyloxy group -C(O)-O- or an oxycarbonyl group -O-C(O)-. Preferably this group is straight-chain and has 2 to 6 C

atoms. It is accordingly preferably acetyloxy, propionyloxy, butyryloxy, pentanoyloxy, hexanoyloxy, acetyloxymethyl, propionyloxymethyl, butyryloxymethyl, pentanoyloxymethyl, 2-acetyloxyethyl, 2-propionyloxyethyl, 2-butyryloxyethyl, 3-acetyloxypropyl, 3-propionyloxypropyl, 4-acetyloxybutyl, methoxycarbonyl, ethoxycarbonyl, propoxycarbonyl, butoxycarbonyl, pentoxycarbonyl, methoxycarbonylmethyl, ethoxycarbonylmethyl, propoxycarbonylmethyl, butoxycarbonylmethyl, 2-(methoxycarbonyl)ethyl, 2-(ethoxycarbonyl)ethyl, 2-(propoxycarbonyl)ethyl, 3-(methoxycarbonyl)propyl, 3-(ethoxycarbonyl)propyl, 4-(methoxycarbonyl)-butyl.

An alkyl group wherein two or more CH₂ groups are replaced by -O- and/or -C(O)O- can be straight-chain or branched. It is preferably straight-chain and has 3 to 12 C atoms. Accordingly it is preferably bis-carboxymethyl, 2,2-bis-carboxy-ethyl, 3,3-bis-carboxy-propyl, 4,4-bis-carboxy-butyl, 5,5-bis-carboxy-pentyl, 6,6-bis-carboxy-hexyl, 7,7-bis-carboxy-heptyl, 8,8-bis-carboxy-octyl, 9,9-bis-carboxy-nonyl, 10,10-bis-carboxy-decyl, bis-(methoxycarbonyl)-methyl, 2,2-bis-(methoxycarbonyl)-ethyl, 3,3-bis-(methoxycarbonyl)-propyl, 4,4-bis-(methoxycarbonyl)-butyl, 5,5-bis-(methoxycarbonyl)-pentyl, 6,6-bis-(methoxycarbonyl)-hexyl, 7,7-bis-(methoxycarbonyl)-heptyl, 8,8-bis-(methoxycarbonyl)-octyl, bis-(ethoxycarbonyl)-methyl, 2,2-bis-(ethoxycarbonyl)-ethyl, 3,3-bis-(ethoxycarbonyl)-propyl, 4,4-bis-(ethoxycarbonyl)-butyl, 5,5-bis-(ethoxycarbonyl)-hexyl.

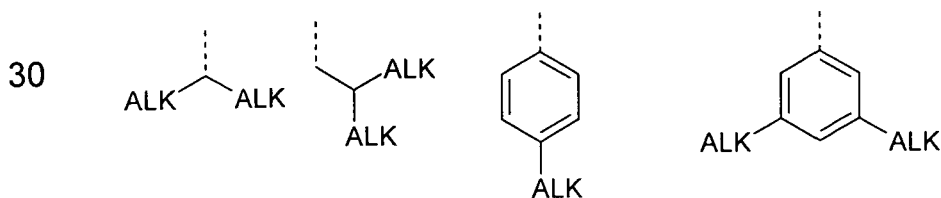
A thioalkyl group, i.e. where one CH₂ group is replaced by -S-, is preferably straight-chain thiomethyl (-SCH₃), 1-thioethyl (-SCH₂CH₃), 1-thiopropyl (= -SCH₂CH₂CH₃), 1-(thiobutyl), 1-(thiopentyl), 1-(thiohexyl), 1-(thioheptyl), 1-(thiooctyl), 1-(thiononyl), 1-(thiodecyl), 1-(thioundecyl) or 1-(thiododecyl), wherein preferably the CH₂ group adjacent to the sp² hybridised vinyl carbon atom is replaced.

A fluoroalkyl group is preferably straight-chain perfluoroalkyl C_iF_{2i+1}, wherein i is an integer from 1 to 15, in particular CF₃, C₂F₅, C₃F₇, C₄F₉, C₅F₁₁, C₆F₁₃, C₇F₁₅ or C₈F₁₇, very preferably C₆F₁₃.

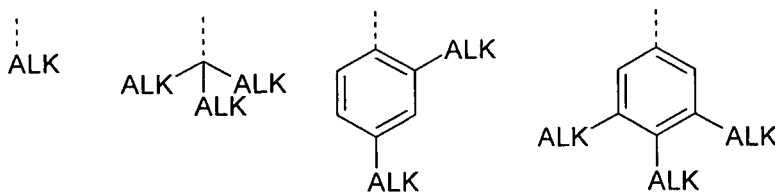
The above-mentioned alkyl, alkoxy, alkenyl, oxaalkyl, thioalkyl, carbonyl and carbonyloxy groups can be achiral or chiral groups. Particularly preferred chiral groups are 2-butyl (=1-methylpropyl), 2-methylbutyl, 2-methylpentyl, 3-methylpentyl, 2-ethylhexyl, 2-propylpentyl, in particular 2-methylbutyl, 2-methylbutoxy, 2-methylpentoxy, 3-methylpentoxy, 2-ethylhexoxy, 1-methylhexoxy, 2-octyloxy, 2-oxa-3-methylbutyl, 3-oxa-4-methylpentyl, 4-methylhexyl, 2-hexyl, 2-octyl, 2-nonyl, 2-decyl, 2-dodecyl, 6-methoxyoctoxy, 6-methyloctoxy, 6-methyloctanoyloxy, 5-methylheptyloxy-carbonyl, 2-methylbutyryloxy, 3-methylvaleroyloxy, 4-methylhexanoyloxy, 2-chloropropionyloxy, 2-chloro-3-methylbutyryloxy, 2-chloro-4-methyl-valeryl-oxy, 2-chloro-3-methylvaleryloxy, 2-methyl-3-oxapentyl, 2-methyl-3-oxa-hexyl, 1-methoxypropyl-2-oxy, 1-ethoxypropyl-2-oxy, 1-propoxypropyl-2-oxy, 1-butoxypropyl-2-oxy, 2-fluorooctyloxy, 2-fluorodecyloxy, 1,1,1-trifluoro-2-octyloxy, 1,1,1-trifluoro-2-octyl, 2-fluoromethyloctyloxy for example. Very preferred are 2-hexyl, 2-octyl, 2-octyloxy, 1,1,1-trifluoro-2-hexyl, 1,1,1-trifluoro-2-octyl and 1,1,1-trifluoro-2-octyloxy.

Preferred achiral branched groups are isopropyl, isobutyl (=methylpropyl), isopentyl (=3-methylbutyl), tert. butyl, isopropoxy, 2-methyl-propoxy and 3-methylbutoxy.

In another preferred embodiment of the present invention, R¹, R² or R³ is selected from primary, secondary or tertiary alkyl or alkoxy with 1 to 30 C atoms, wherein one or more H atoms are optionally replaced by F, or aryl, aryloxy, heteroaryl or heteroaryloxy that is optionally alkylated or alkoxyated and has 4 to 30 ring atoms. Very preferred groups of this type are selected from the group consisting of the following formulae



5



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wherein "ALK" denotes optionally fluorinated, preferably linear, alkyl or alkoxy with 1 to 20, preferably 1 to 12 C-atoms, in case of tertiary groups very preferably 1 to 9 C atoms, and the dashed line denotes the link to the ring to which these groups are attached. Especially preferred among these groups are those wherein all ALK subgroups are identical.

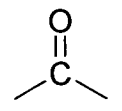
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-CY¹=CY²- is preferably -CH=CH-, -CF=CF- or -CH=C(CN)-.

Halogen is F, Cl, Br or I, preferably F, Cl or Br.

20

"-CO-", "-C(=O)-" and "-C(O)-" denote a carbonyl group, i.e.



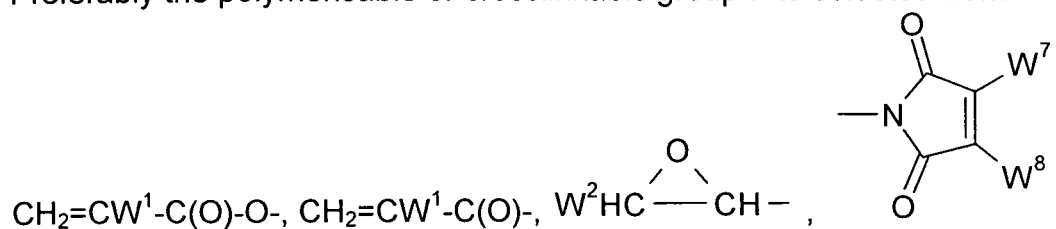
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

The polymers may also be substituted with a polymerisable or crosslinkable reactive group, which is optionally protected during the process of forming the polymer. Particular preferred polymers of this type are those of formula I wherein R¹ denotes P-Sp. These polymers are particularly useful as semiconductors or charge transport materials, as they can be crosslinked via the groups P, for example by polymerisation in situ, during or after processing the polymer into a thin film for a semiconductor component, to yield crosslinked polymer films with high charge carrier mobility and high thermal, mechanical and chemical stability.

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Preferably the polymerisable or crosslinkable group P is selected from




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 W^2  $(CH_2)_{k_1}-O-$, $CH_2=CW^2-(O)_{k_1}-$, $CW^1=CH-C(O)-(O)_{k_3}-$, $CW^1=CH-C(O)-NH-$, $CH_2=CW^1-C(O)-NH-$, $CH_3-CH=CH-O-$, $(CH_2=CH)_2CH-OC(O)-$,
 5 $(CH_2=CH-CH_2)_2CH-O-C(O)-$, $(CH_2=CH)_2CH-O-$, $(CH_2=CH-CH_2)_2N-$,
 $(CH_2=CH-CH_2)_2N-C(O)-$, $HO-CW^2W^3-$, $HS-CW^2W^3-$, HW^2N- , $HO-CW^2W^3-$
 $NH-$, $CH_2=CH-(C(O)-O)_{k_1}-Phe-(O)_{k_2}-$, $CH_2=CH-(C(O))_{k_1}-Phe-(O)_{k_2}-$, $Phe-$
 10 $CH=CH-$, $HOOC-$, $OCN-$, and $W^4W^5W^6Si-$, with W^1 being H, F, Cl, CN,
 CF_3 , phenyl or alkyl with 1 to 5 C-atoms, in particular H, Cl or CH_3 , W^2 and
 W^3 being independently of each other H or alkyl with 1 to 5 C-atoms, in
 particular H, methyl, ethyl or n-propyl, W^4 , W^5 and W^6 being independently
 of each other Cl, oxaalkyl or oxacarbonylalkyl with 1 to 5 C-atoms, W^7 and
 W^8 being independently of each other H, Cl or alkyl with 1 to 5 C-atoms,
 15 Phe being 1,4-phenylene that is optionally substituted by one or more
 groups L as defined above, k_1 , k_2 and k_3 being independently of each
 other 0 or 1, k_3 preferably being 1, and k_4 being an integer from 1 to 10.

20 Alternatively P is a protected derivative of these groups which is non-
 reactive under the conditions described for the process according to the
 present invention. Suitable protective groups are known to the ordinary
 expert and described in the literature, for example in Green, "Protective
 Groups in Organic Synthesis", John Wiley and Sons, New York (1981),
 like for example acetals or ketals.

25 Especially preferred groups P are $CH_2=CH-C(O)-O-$, $CH_2=C(CH_3)-C(O)-O-$,
 $CH_2=CF-C(O)-O-$, $CH_2=CH-O-$, $(CH_2=CH)_2CH-O-C(O)-$, $(CH_2=CH)_2CH-$


 $O-$, W^2HC  $CH-$ and W^2  $(CH_2)_{k_1}-O-$, or protected derivatives
 30 thereof. Further preferred groups P are selected from the group consisting
 of vinyloxy, acrylate, methacrylate, fluoroacrylate, chloracrylate, oxetan
 and epoxy groups, very preferably from an acrylate or methacrylate group.

35 Polymerisation of group P can be carried out according to methods that are
 known to the ordinary expert and described in the literature, for example in
 D. J. Broer; G. Challa; G. N. Mol, *Macromol. Chem*, 1991, **192**, 59.

The term "spacer group" is known in prior art and suitable spacer groups Sp are known to the ordinary expert (see e.g. Pure Appl. Chem. 73(5), 888 (2001)). The spacer group Sp is preferably of formula Sp'-X', such that P-Sp- is P-Sp'-X'-, wherein

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Sp' is alkylene with up to 30 C atoms which is unsubstituted or mono- or polysubstituted by F, Cl, Br, I or CN, it being also possible for one or more non-adjacent CH₂ groups to be replaced, in each case independently from one another, by -

10

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X' is -O-, -S-, -C(O)-, -C(O)O-, -OC(O)-, -O-C(O)O-, -C(O)-NR⁰-, -NR⁰-C(O)-, -NR⁰-C(O)-NR⁰⁰-, -OCH₂-, -CH₂O-, -SCH₂-, -CH₂S-, -CF₂O-, -OCF₂-, -CF₂S-, -SCF₂-, -CF₂CH₂-, -CH₂CF₂-, -CF₂CF₂-, -CH=N-, -N=CH-, -N=N-, -CH=CR⁰-, -CY¹=CY²-, -C≡C-, -CH=CH-C(O)O-, -OC(O)-CH=CH- or a single bond,

20

R⁰ and R⁰⁰ are independently of each other H or alkyl with 1 to 12 C-atoms, and

Y¹ and Y² are independently of each other H, F, Cl or CN.

25

X' is preferably -O-, -S-, -OCH₂-, -CH₂O-, -SCH₂-, -CH₂S-, -CF₂O-, -OCF₂-, -CF₂S-, -SCF₂-, -CH₂CH₂-, -CF₂CH₂-, -CH₂CF₂-, -CF₂CF₂-, -CH=N-, -N=CH-, -N=N-, -CH=CR⁰-, -CY¹=CY²-, -C≡C- or a single bond, in particular -O-, -S-, -C≡C-, -CY¹=CY²- or a single bond. In another preferred embodiment X' is a group that is able to form a conjugated system, such as -C≡C- or -CY¹=CY²-, or a single bond.

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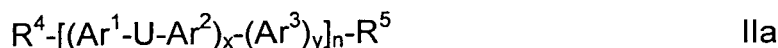
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Typical groups Sp' are, for example, -(CH₂)_p-, -(CH₂CH₂O)_q-CH₂CH₂-, -CH₂CH₂-S-CH₂CH₂- or -CH₂CH₂-NH-CH₂CH₂- or -(SiR⁰R⁰⁰-O)_p-, with p being an integer from 2 to 12, q being an integer from 1 to 3 and R⁰ and R⁰⁰ having the meanings given above.

Preferred groups Sp' are ethylene, propylene, butylene, pentylene, hexylene, heptylene, octylene, nonylene, decylene, undecylene, dodecylene, octadecylene, ethyleneoxyethylene, methyleneoxybutylene, ethylene-thioethylene, ethylene-N-methyl-iminoethylene, 1-methylalkylene, ethenylene, propenylene and butenylene for example.

The polymers containing moieties of formula I, especially those of formula II, are preferably selected of formula IIa

10



wherein U, Ar¹⁻³, n, x and y have the meanings of formula I and II, and

15

R⁴ and R⁵ have independently of each other one of the meanings of R¹, preferably F, Cl or Br, or denote -CH₂Cl, -CHO, -CH=CH₂, -SiR'R''R''', -SiX'X''R', -SiR'R''X', -SnR'R''R''', -BR'R'', -B(OR')(OR''), -B(OH)₂, O-SO₂-R', -ZnX', -C≡CH, -C≡C-SiR'R''R''' or P-Sp-, wherein P and Sp are as defined above, and R', R'' and R''' have independently of each other one of the meanings of R⁰ as defined above, and two of R', R'' and R''' may also form a ring together with the hetero atom to which they are attached, and X' and X'' are a halogen atom.

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In the polymers according to the the present invention, the total number of repeating units n is preferably ≥ 5, very preferably ≥ 10, most preferably ≥ 50, and preferably up to 500, very preferably up to 1,000, most preferably up to 2,000, including any combination of the aforementioned lower and upper limits of n.

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The polymers of the present invention include homopolymers and copolymers, like statistical or random copolymers, alternating copolymers and block copolymers, as well as combinations thereof.

35

Block copolymers may for example comprise or consist of one or more blocks formed by units of formula I and one or more blocks formed by

units Ar^3 , wherein Ar^3 has one of the meanings of formula II or as described above and below.

Especially preferred are polymers selected from the following groups:

5

- Group A consisting of homopolymers of the unit U or (Ar^1-U) or (Ar^1-U-Ar^2) or (Ar^1-U-Ar^3) or $(U-Ar^2-Ar^3)$ or $(Ar^1-U-Ar^2-Ar^3)$, i.e. where all repeating units are identical,

10

- Group B consisting of random or alternating copolymers formed by identical units (Ar^1-U-Ar^2) and identical units (Ar^3) ,

- Group C consisting of random or alternating copolymers formed by identical units (Ar^1-U) and identical units (Ar^2-Ar^3) ,

15

- Group D consisting of random or alternating copolymers formed by identical units (U) and identical units $(Ar^2-A^3-Ar^1)$,

20

wherein in all these groups U, D^1 , Ar^1 , Ar^2 and Ar^3 are as defined above and below, and in group A Ar^1 and Ar^2 are different from a single bond, and in groups B, C and D one of Ar^1 and Ar^2 may also denote a single bond.

Another aspect of the invention relates to monomers of formula Ia

25



wherein U, Ar^1 , Ar^2 , R^4 and R^5 have the meanings of formula II and IIa, or one of the preferred meanings as described above and below.

30

Especially preferred are monomers of formula Ia wherein R^4 and R^5 are independently of each other selected from the group consisting of Cl, Br, I, O-tosylate, O-triflate, O-mesylate, O-nonaflate, $-SiMe_2F$, $-SiMeF_2$, $-O-SO_2Z^1$, $-B(OZ^2)_2$, $-CZ^3=C(Z^3)_2$, $-C\equiv CH$, $-ZnX$, $-C\equiv C-Si(Z^3)_3$ and $-Sn(Z^4)_3$, wherein X is halogen, Z^{1-4} are selected from the group consisting of alkyl and aryl, each being optionally substituted, and two groups Z^2 may also form a cyclic group.

35

Preferably the moieties of formula I, the monomers of formula Ia, and the polymers of formula II and IIa containing them, are selected from the following list of preferred embodiments:

- 5
- one of Ar¹ and Ar² is a single bond,
 - both Ar¹ and Ar² are a single bond,
 - both Ar¹ and Ar² are not a single bond,
- 10
- Ar¹ and Ar², when being different from a single bond, are selected from the group consisting of thiophene-2,5-diyl, thiazole-2,5-diyl, selenophene-2,5-diyl, furan-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl, thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, or selenopheno[2,3-b]thiophene-2,5-diyl, all of
- 15
- which are unsubstituted, or mono- or polysubstituted, preferably with R³ as defined above and below,
- Ar³ is selected from the group consisting of 1,4-phenylene, thiophene-2,5-diyl, selenophene-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl,
- 20
- thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, selenopheno[2,3-b]thiophene-2,5-diyl, benzo[1,2-b:4,5-b']dithiophene-2,6-diyl, 2,2-dithiophene, 2,2-diselenophene, dithieno[3,2-b:2',3'-d]silole-5,5-diyl, 4*H*-cyclopenta[2,1-b:3,4-
- 25
- b'*]dithiophene-2,6-diyl, carbazole-2,7-diyl, fluorene-2,7-diyl, indaceno[1,2-b:5,6-b']dithiophene-2,7-diyl, benzo[1'',2'':4,5;4'',5'':4',5']bis(silolo[3,2-b:3',2'-b']thiophene)-2,7-diyl, phenanthro[1,10,9,8-*c,d,e,f,g*]carbazole-2,7-diyl, benzo[2,1,3]thiadiazole-4,7-diyl, benzo[2,1,3]selenadiazole-4,7-diyl, benzo[2,1,3]oxadiazole-4,7-diyl, 2*H*-benzotriazole-4,7-diyl, thieno[3,4-b]pyrazine-2,5-diyl, quinoxaline-5,8-diyl, thieno[3,4-b]thiophene-4,6-diyl, thieno[3,4-b]thiophene-6,4-diyl, 3,6-di-thien-2-yl-pyrrolo[3,4-*c*]pyrrole-1,4-dione, or [1,3]thiazolo[5,4-*d*][1,3]thiazole-2,5-diyl, thieno[2,1,3]thiadiazole-2,5-diyl, 2-thia-1,3,5,8-tetraaza-cyclopenta[*b*]naphthalene-4,9-diyl, thieno[3,4-*c*]pyrrole-4,6-dione-1,3-diyl, benzo[*lmn*][3,8]phenanthroline-1,3,6,8-tetraone-4,9-diyl, all of which are unsubstituted, or mono- or
- 35

polysubstituted, preferably with R^1 , R^2 or R^3 as defined above and below,

- 5
- n is at least 5, preferably at least 10, very preferably at least 50, and up to 2,000, preferably up to 500.
 - M_w is at least 5,000, preferably at least 8,000, very preferably at least 10,000, and preferably up to 300,000, very preferably up to 100,000,
 - R^1 and R^2 are selected from the group consisting of primary alkyl or alkoxy with 1 to 30 C atoms, secondary alkyl or alkoxy with 3 to 30 C atoms, and tertiary alkyl or alkoxy with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,
 - R^1 and R^2 are selected from the group consisting of $-C(O)-R^6$, $-C(O)-O-R^6$, $-O-C(O)-R^6$, wherein R^6 is straight-chain, branched or cyclic alkyl with 1 to 30 C atoms, in which one or more non-adjacent C atoms are optionally replaced by $-O-$, $-S-$, $-C(O)-$, $-C(O)-O-$, $-O-C(O)-$, $-O-C(O)-O-$, $-CR^0=CR^{00}-$ or $-C\equiv C-$ and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN,
- 10
- wherein preferably R^6 is primary alkyl with 1 to 30 C atoms, very preferably with 1 to 15 C atoms, secondary alkyl with 3 to 30 C atoms, or tertiary alkyl with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,
- 15
- R^1 and R^2 are selected from the group consisting of aryl, aryloxy, heteroaryl and heteroaryloxy, each of which has 4 to 30 ring atoms and is unsubstituted or substituted by one or more halogen atoms or by one or more groups R^6 , $-OR^6$, $-C(O)-R^6$, $-C(O)-O-R^6$, or $-O-C(O)-R^6$ wherein R^6 is as defined above,
- 20
- wherein preferably R^6 is primary alkyl with 1 to 30 C atoms, very preferably with 1 to 15 C atoms, secondary alkyl with 3 to 30 C atoms, or tertiary alkyl with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,
- 25
- R^3 is F, Cl, Br, I, CN, R^6 , $-C(O)-R^6$, $-C(O)-O-R^6$, or $-O-C(O)-R^6$, or R^3 is aryl, aryloxy, heteroaryl or heteroaryloxy each of which has 4 to 30 ring atoms and is unsubstituted or substituted by one or more halogen
- 30
- 35

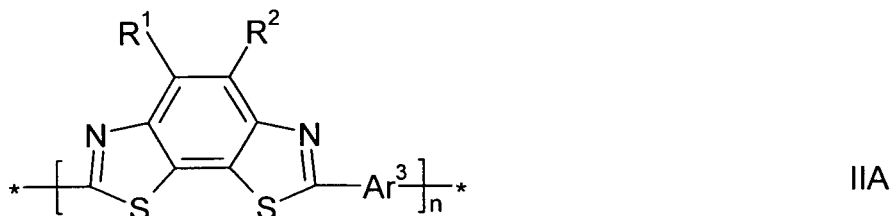
atoms or by one or more groups R^6 , $-C(O)-R^6$, $-C(O)-O-R^6$, or $-O-C(O)-R^6$, wherein R^6 is as defined above,

- R^0 and R^{00} are selected from H or C_1-C_{10} -alkyl,
- 5 - R^4 and R^5 are selected from H, halogen, $-CH_2Cl$, $-CHO$, $-CH=CH_2$, $-SiR'R''R'''$, $-SnR'R''R'''$, $-BR'R''$, $-B(OR')(OR'')$, $-B(OH)_2$, P-Sp, C_1-C_{20} -alkyl, C_1-C_{20} -alkoxy, C_2-C_{20} -alkenyl, C_1-C_{20} -fluoroalkyl and optionally substituted aryl or heteroaryl,
- R^4 and R^5 are independently of each other selected from the group
10 consisting of Cl, Br, I, O-tosylate, O-triflate, O-mesylate, O-nonaflate, $-SiMe_2F$, $-SiMeF_2$, $-O-SO_2Z^1$, $-B(OZ^2)_2$, $-CZ^3=C(Z^4)_2$, $-C\equiv CH-ZnX$, $-C\equiv C-Si(Z^3)_3$ and $-Sn(Z^4)_3$, wherein X is halogen, Z^{1-4} are selected from the group consisting of alkyl and aryl, each being optionally substituted, and two groups Z^2 may also form a cyclic group, very preferably from Br.

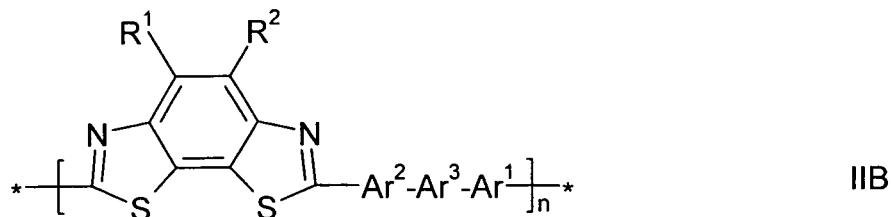
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Preferred polymers of formula II are selected from the group consisting of the following formulae:

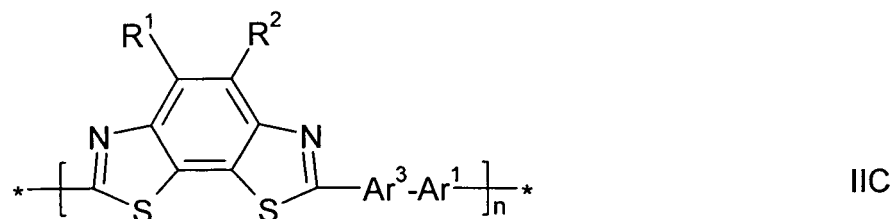
20



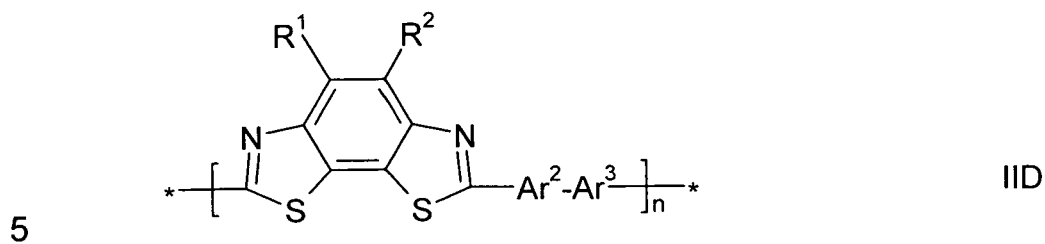
25



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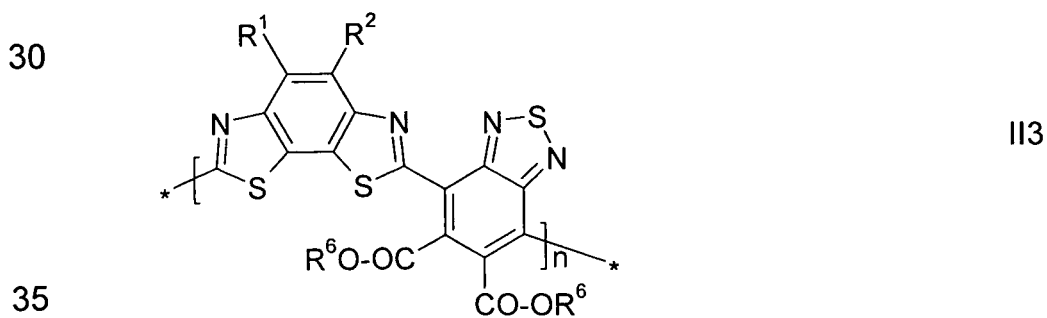
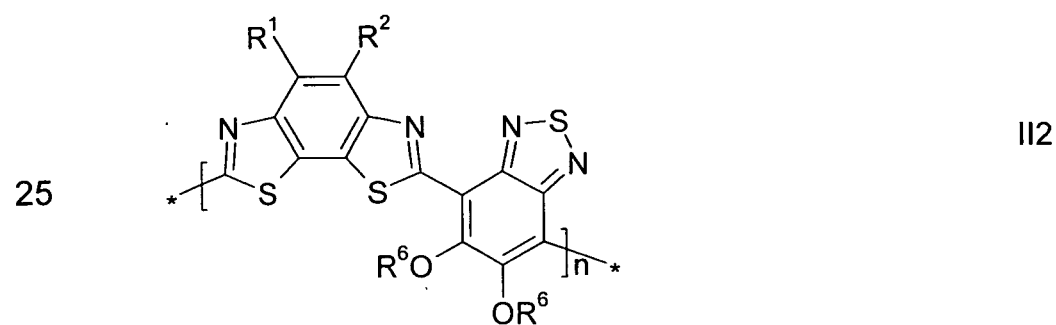
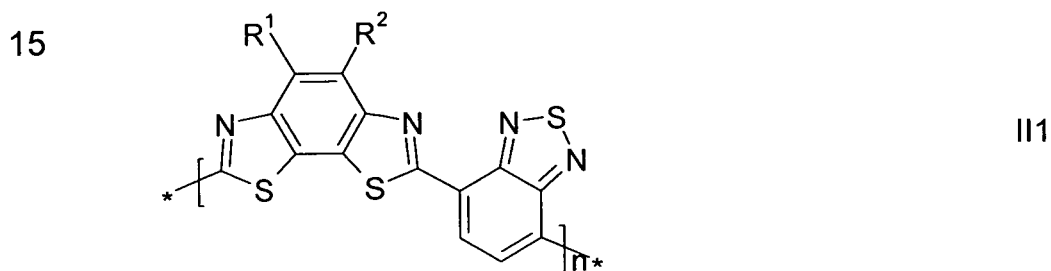
35

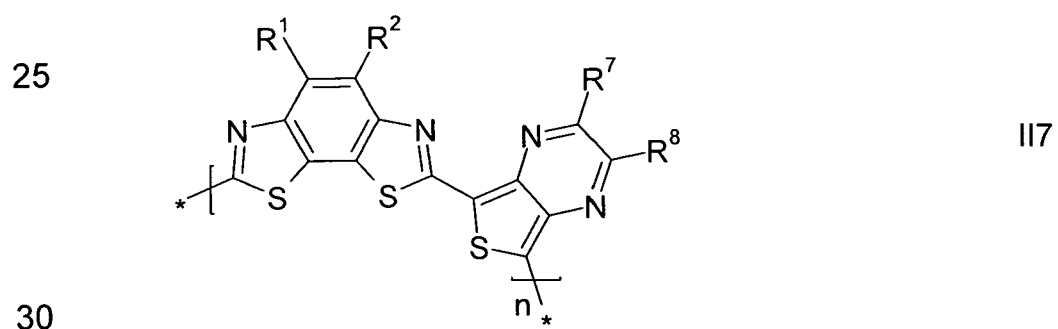
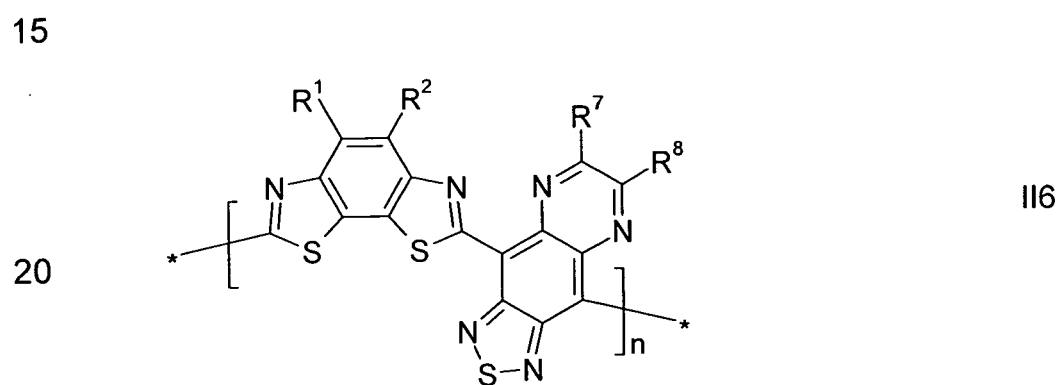
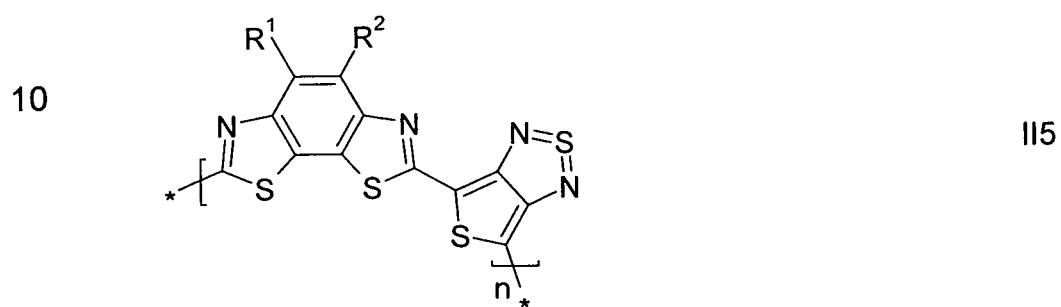
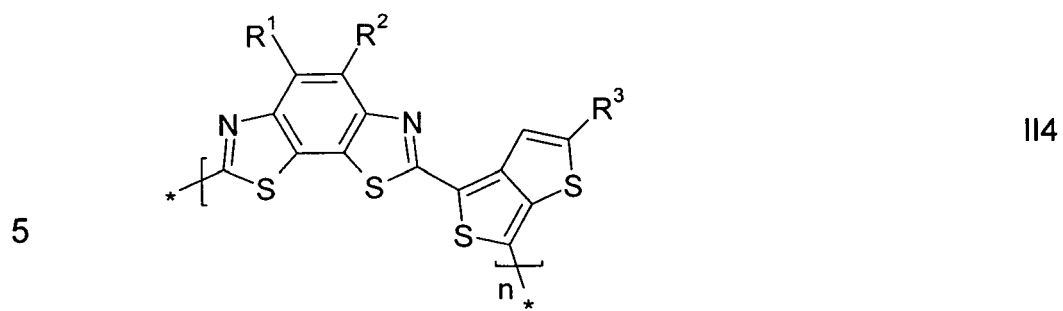


wherein R¹, R², Ar¹, Ar², Ar³ and n have the meanings given above and below, and wherein Ar¹, Ar² and Ar³ do not denote a single bond.

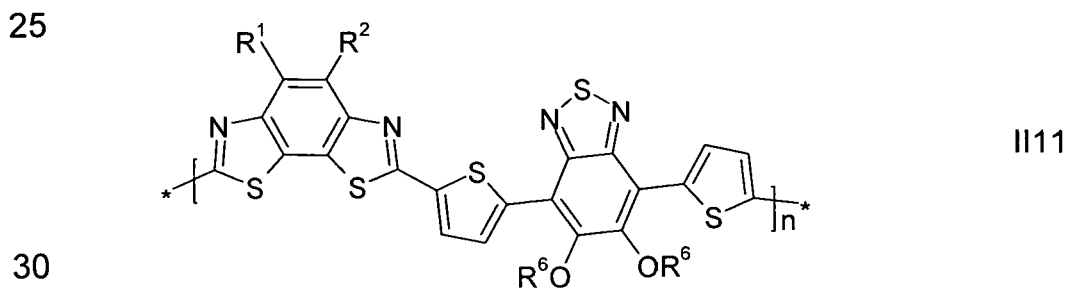
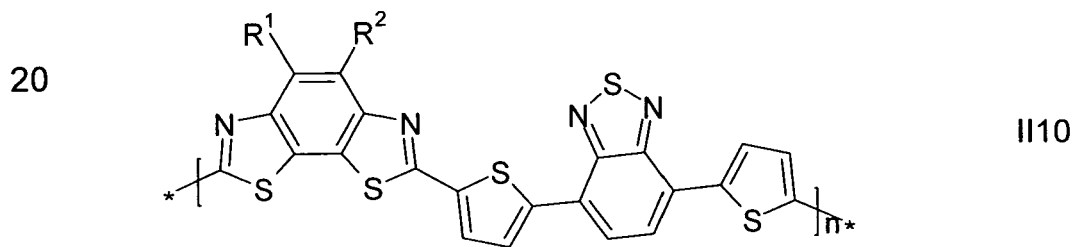
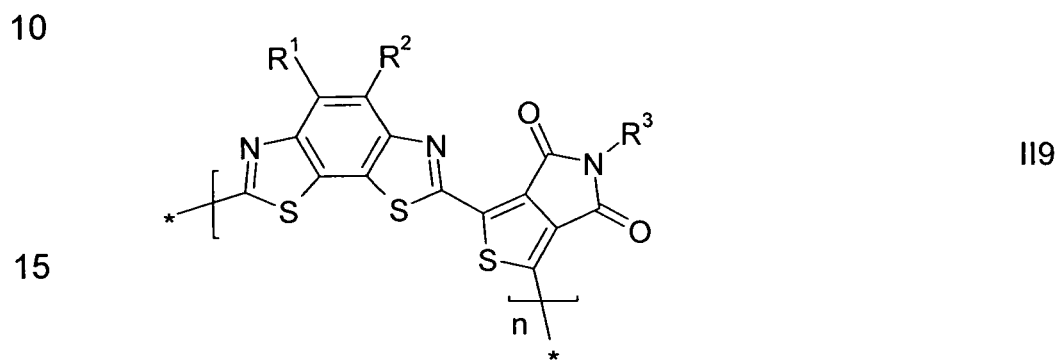
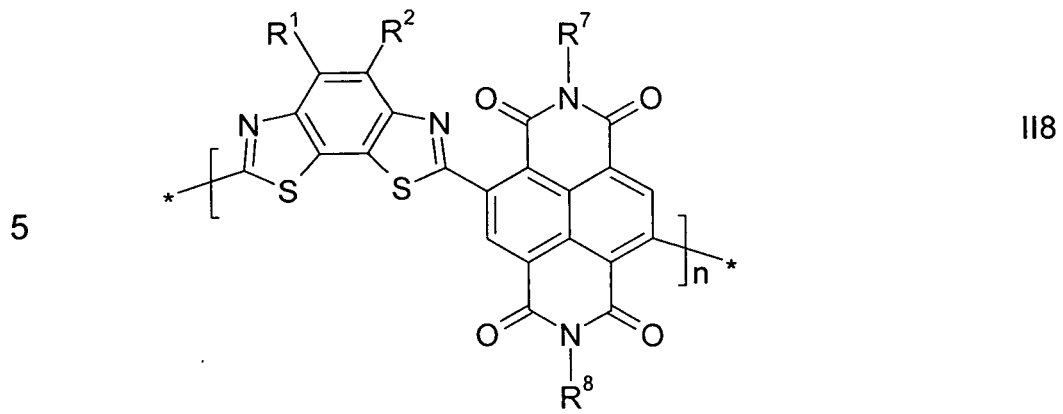
10 Especially preferred are polymers of formulae IIA and IIB.

Very preferred polymers of formulae II and IIA-IIID are selected from the group consisting of the following formulae:

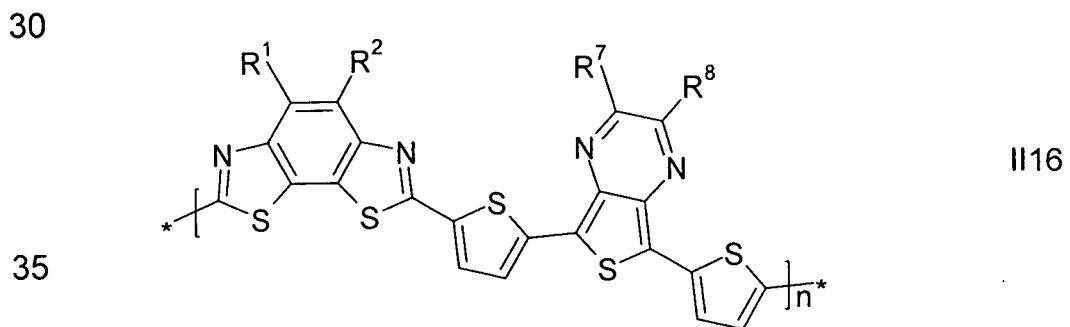
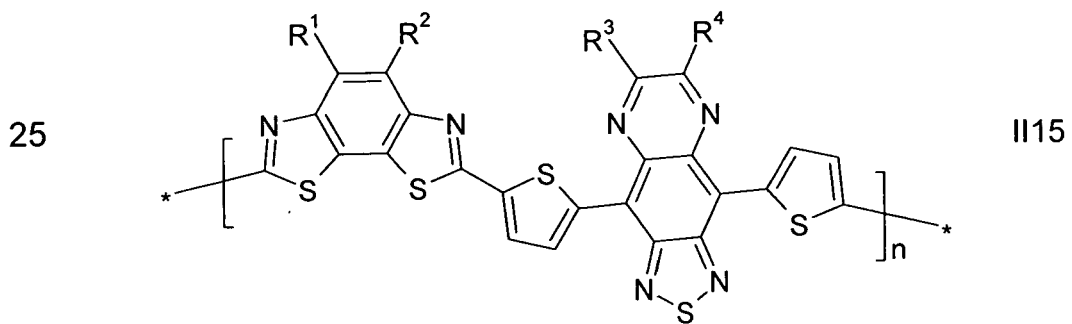
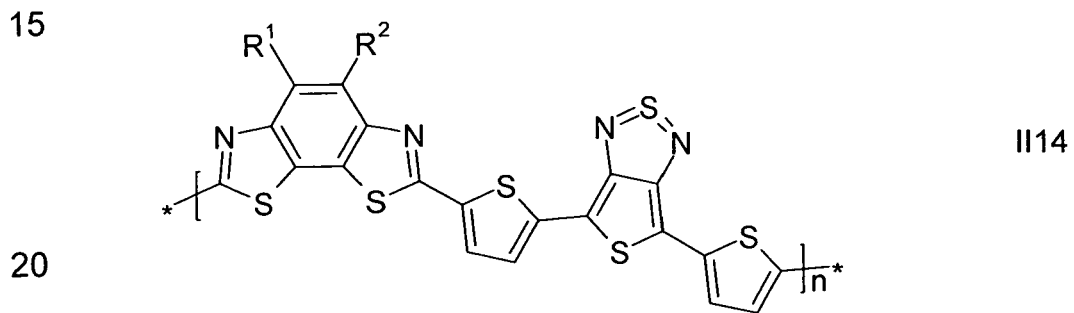
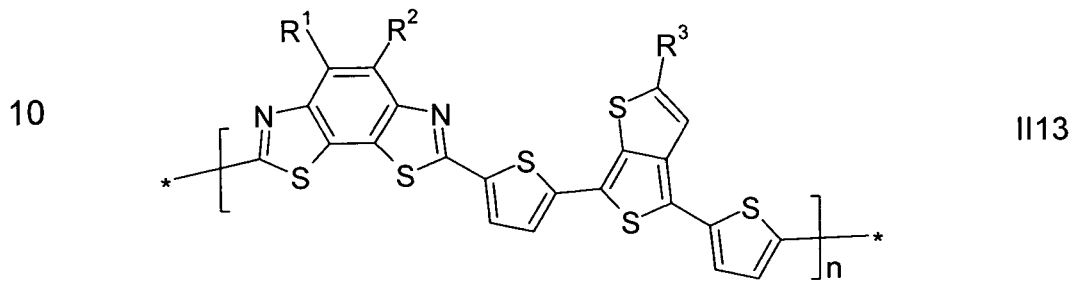
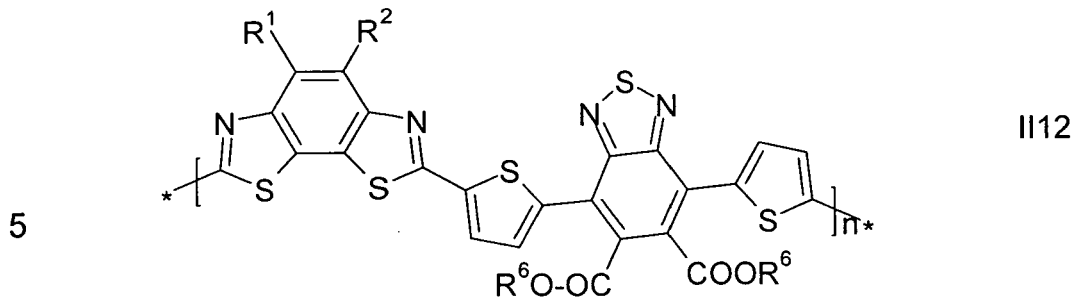


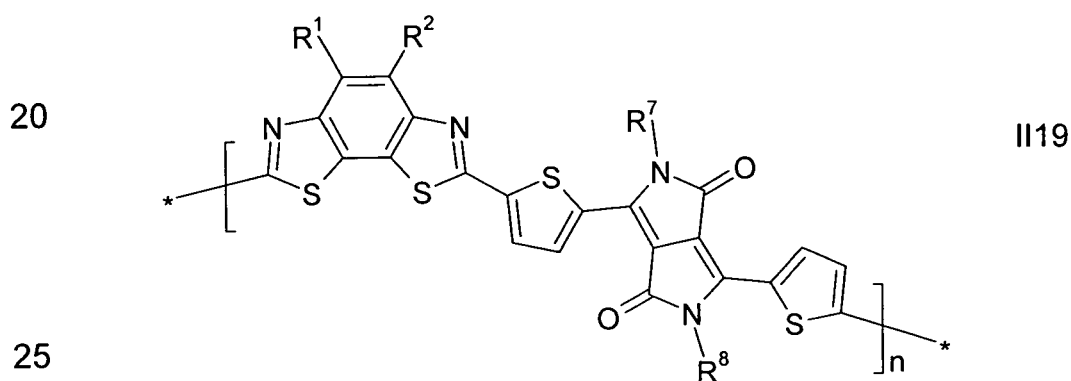
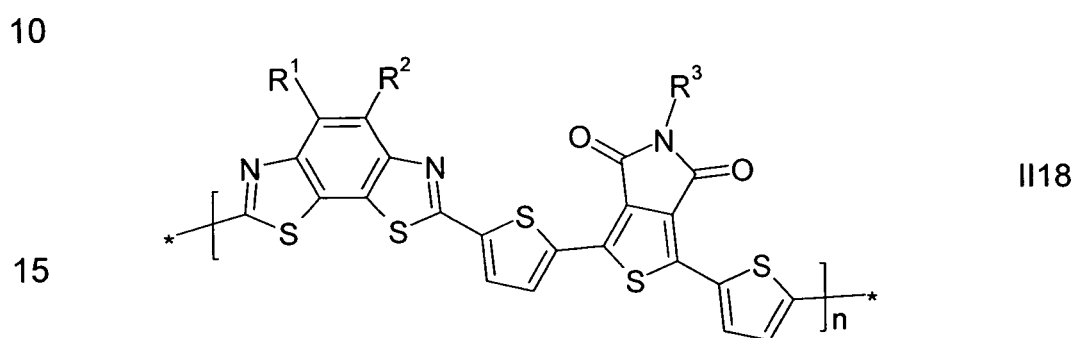
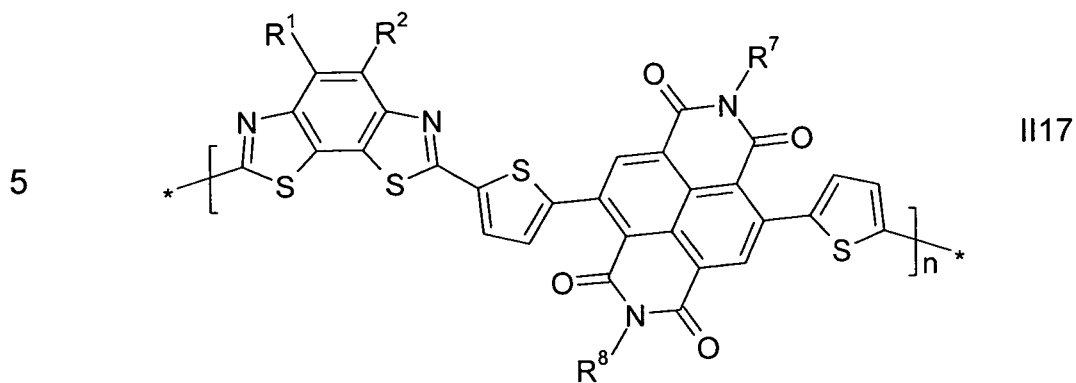


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wherein R^1 , R^2 , R^3 , R^6 and n have the meanings as given in formula I and II or one of the preferred meanings as given above and below, and R^7 and R^8 have independently of each other one of the meanings of R^3 or its preferred meanings as given above and below.

30

Preferred polymers of formula IIa are selected of the formula

35 R^4 -chain- R^5

wherein "chain" is a polymer chain selected from above formulae IIA-IID

and II1-15, and R⁴ and R⁵ have one of the meanings given in formula IIa or one of the preferred meanings given above and below.

5 The polymers of the present invention can be synthesized according to or in analogy to methods that are known to the skilled person and are described in the literature. Other methods of preparation can be taken from the examples. For example, they can be suitably prepared by aryl-aryl coupling reactions, such as Yamamoto coupling, Suzuki coupling, Stille coupling, Sonogashira coupling, Heck coupling or Buchwald
10 coupling. Suzuki coupling and Yamamoto coupling are especially preferred.

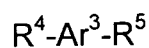
15 The monomers which are polymerised to form the repeat units of the polymers can be prepared according to methods which are known to the person skilled in the art.

Preferably the polymers are prepared from monomers of formula Ia or its preferred embodiments as described above and below.

20 Another aspect of the invention is a process for preparing a polymer by coupling one or more identical or different monomeric units of formula I or monomers of formula Ia with each other and/or with one or more comonomers in a polymerisation reaction, preferably in an aryl-aryl coupling reaction.

25

Suitable and preferred comonomers are those of the formula



30 wherein R⁴ and R⁵ have one of the meanings of formula IIa or one of the preferred meanings given above and below, and Ar³ has one of the meanings of formula IIa or of Ar in formula IIa, or one of the preferred meanings given above and below.

35 Preferred methods for polymerisation are those leading to C-C-coupling or C-N-coupling, like Suzuki polymerisation, as described for example in WO

00/53656, Yamamoto polymerisation, as described in for example in T. Yamamoto et al., Progress in Polymer Science 1993, 17, 1153-1205 or in WO 2004/022626 A1, and Stille coupling. For example, when synthesizing a linear polymer by Yamamoto polymerisation, monomers as described
5 above having two reactive halide groups R^4 and R^5 is preferably used. When synthesizing a linear polymer by Suzuki polymerisation, preferably a monomer as described above is used wherein at least one reactive group R^4 or R^5 is a boronic acid or boronic acid derivative group.

10 Suzuki polymerisation may be used to prepare homopolymers as well as statistical, alternating and block random copolymers. Statistical or block copolymers can be prepared for example from the above monomers of formula Ia wherein one of the reactive groups R^4 and R^5 is halogen and the other reactive group is a boronic acid or boronic acid derivative group.
15 The synthesis of statistical, alternating and block copolymers is described in detail for example in WO 03/048225 A2 or WO 2005/014688 A2.

Suzuki polymerisation employs a Pd(0) complex or a Pd(II) salt. Preferred Pd(0) complexes are those bearing at least one phosphine ligand such as
20 Pd(Ph_3P)₄. Another preferred phosphine ligand is tris(*ortho*-tolyl)phosphine, i.e. Pd(*o*-Tol)₄. Preferred Pd(II) salts include palladium acetate, i.e. Pd(OAc)₂. Suzuki polymerisation is performed in the presence of a base, for example sodium carbonate, potassium phosphate or an organic base such as tetraethylammonium carbonate. Yamamoto
25 polymerisation employs a Ni(0) complex, for example bis(1,5-cyclooctadienyl) nickel(0).

As alternatives to halogens as described above, leaving groups of formula
30 $-\text{O}-\text{SO}_2\text{Z}^1$ can be used wherein Z^1 is as described above. Particular examples of such leaving groups are tosylate, mesylate and triflate.

Especially suitable and preferred synthesis methods of the repeating units and monomers of formula I and Ia, and their homo- and co-polymers of formula II and IIa, are illustrated in the synthesis schemes shown
35 hereinafter, wherein R, Ar^1 , Ar^2 and Ar^3 are as defined in formula I and II.

A synthesis scheme for the preparation of 2,7-dibromo-benzo[1,2-*d*;4,3-*d'*]bisthiazole is shown in Scheme 1.

Scheme 1

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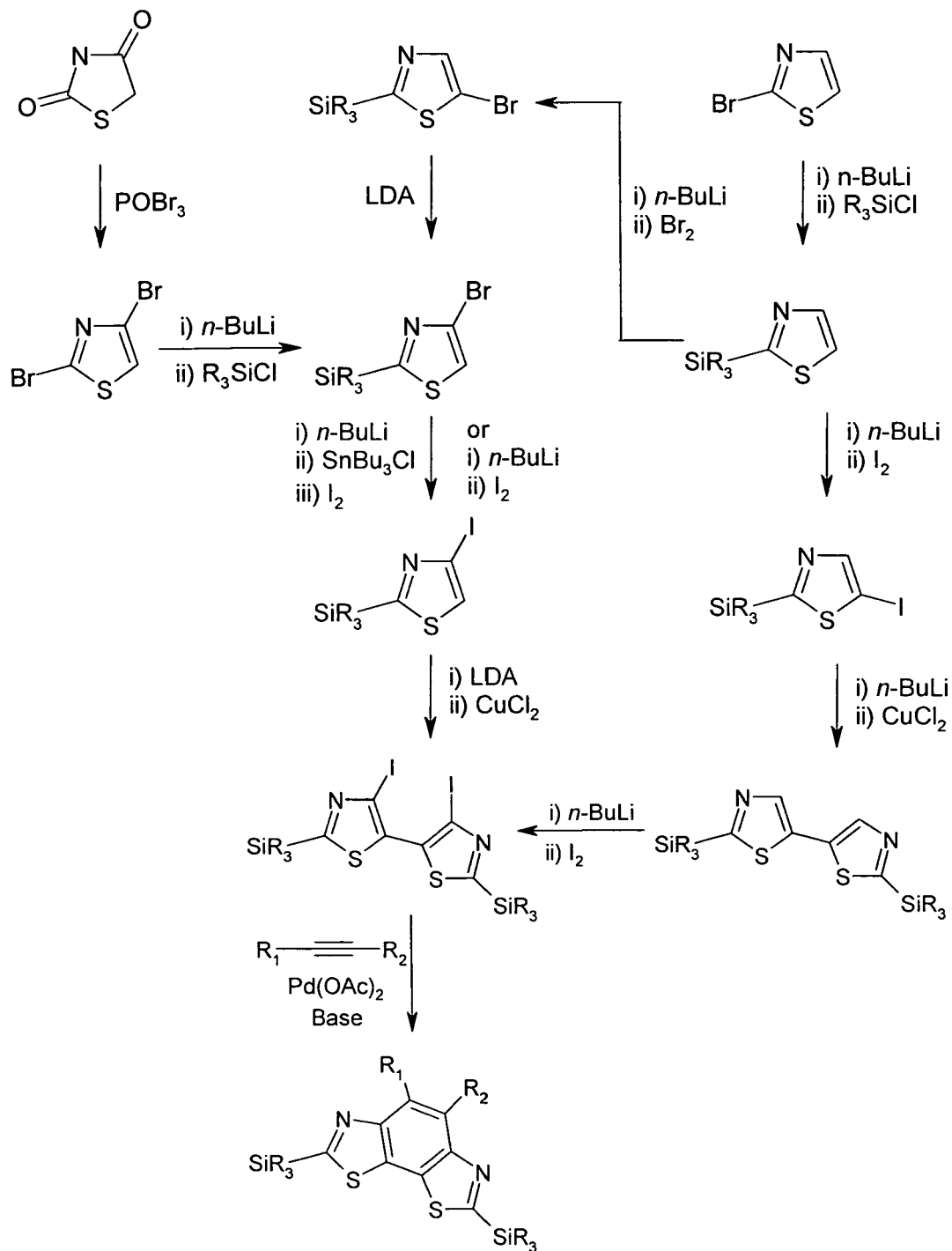
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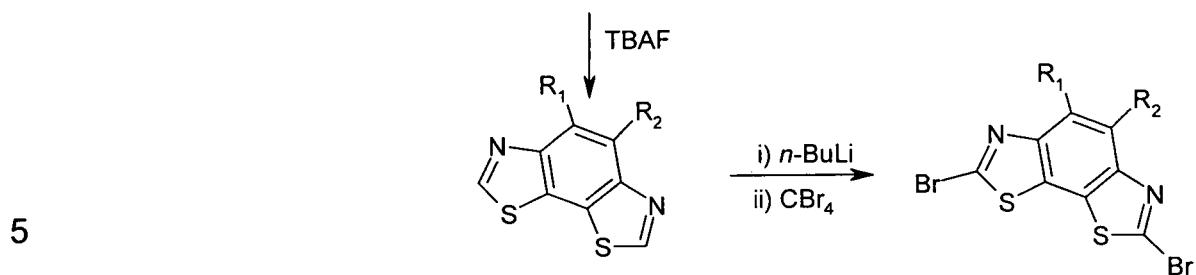
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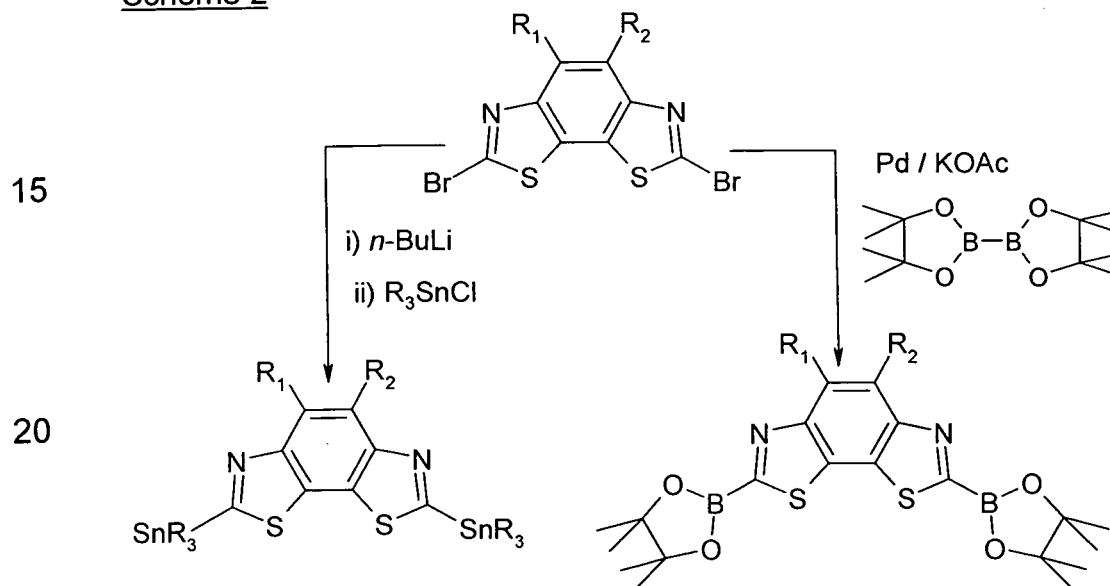




A synthesis scheme for further functionalisation of 2,7-dibromo-benzo[1,2-*d*;4,3-*d'*]bisthiazole is shown in Scheme 2.

10

Scheme 2



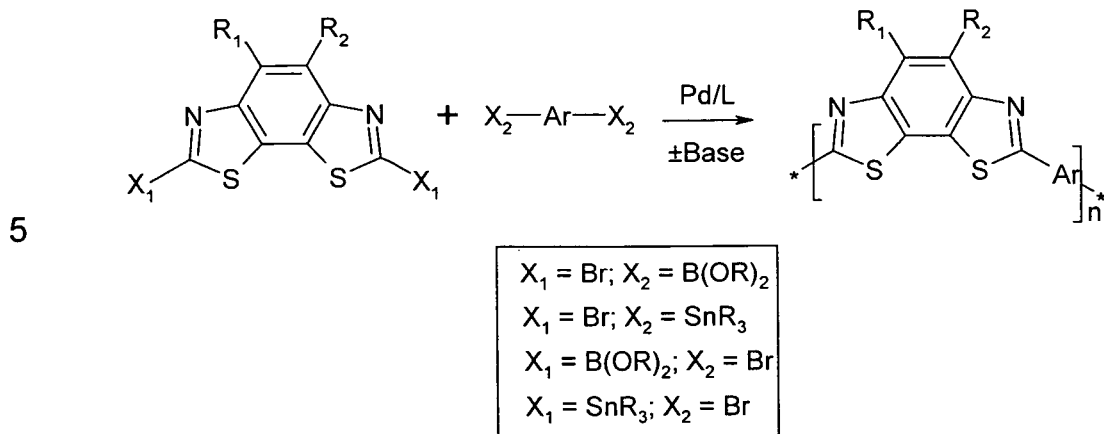
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Synthesis schemes for the co-polymerisation of 2,7-functionalised-benzo[1,2-*d*;4,3-*d'*]bisthiazole are shown in Scheme 3 and 4.

Scheme 3

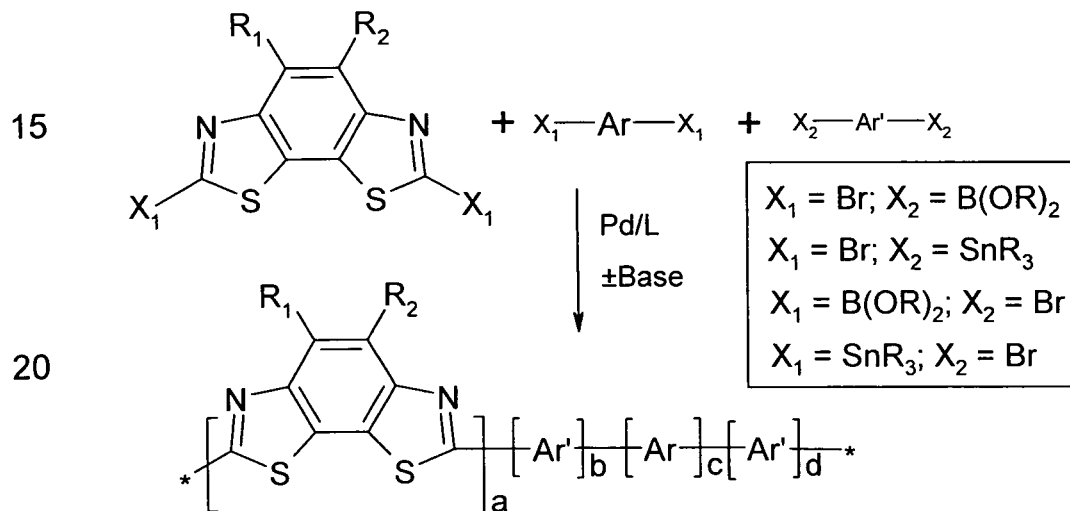
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Scheme 4



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The novel methods of preparing monomers and polymers as described above and below are another aspect of the invention.

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The polymers according to the present invention can also be used in mixtures or polymer blends, for example together with monomeric compounds or together with other polymers having charge-transport, semiconducting, electrically conducting, photoconducting and/or light emitting semiconducting properties, or for example with polymers having hole blocking or electron blocking properties for use as interlayers or charge blocking layers in OLED devices. Thus, another aspect of the invention relates to a polymer blend comprising one or more polymers according to the present invention and one or more further polymers

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having one or more of the above-mentioned properties. These blends can be prepared by conventional methods that are described in prior art and known to the skilled person. Typically the polymers are mixed with each other or dissolved in suitable solvents and the solutions combined.

5

Another aspect of the invention relates to a formulation comprising one or more polymers, mixtures or polymer blends as described above and below and one or more organic solvents.

10

Preferred solvents are aliphatic hydrocarbons, chlorinated hydrocarbons, aromatic hydrocarbons, ketones, ethers and mixtures thereof. Additional solvents which can be used include 1,2,4-trimethylbenzene, 1,2,3,4-tetramethyl benzene, pentylbenzene, mesitylene, cumene, cymene, cyclohexylbenzene, diethylbenzene, tetralin, decalin, 2,6-lutidine, 2-fluoro-m-xylene, 3-fluoro-o-xylene, 2-chlorobenzotrifluoride, dimethylformamide, 2-chloro-6fluorotoluene, 2-fluoroanisole, anisole, 2,3-dimethylpyrazine, 4-fluoroanisole, 3-fluoroanisole, 3-trifluoro-methylanisole, 2-methylanisole, phenetol, 4-methylanisole, 3-methylanisole, 4-fluoro-3-methylanisole, 2-fluorobenzonitrile, 4-fluoroveratrol, 2,6-dimethylanisole, 3-

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fluorobenzonitrile, 2,5-dimethylanisole, 2,4-dimethylanisole, benzonitrile, 3,5-dimethylanisole, N,N-dimethylaniline, ethyl benzoate, 1-fluoro-3,5-dimethoxybenzene, 1-methylnaphthalene, N-methylpyrrolidinone, 3-fluorobenzotrifluoride, benzotrifluoride, benzotrifluoride, diosane, trifluoromethoxybenzene, 4-fluorobenzotrifluoride, 3-fluoropyridine, toluene, 2-fluorotoluene, 2-fluorobenzotrifluoride, 3-fluorotoluene, 4-isopropylbiphenyl, phenyl ether, pyridine, 4-fluorotoluene, 2,5-difluorotoluene, 1-chloro-2,4-difluorobenzene, 2-fluoropyridine, 3-chlorofluorobenzene, 3-chlorofluorobenzene, 1-chloro-2,5-difluorobenzene, 4-chlorofluorobenzene, chlorobenzene, o-dichlorobenzene, 2-chlorofluorobenzene, p-xylene, m-xylene, o-xylene or mixture of o-, m-, and p-isomers. Solvents with relatively low polarity are generally preferred. For inkjet printing solvents with high boiling temperatures and solvent mixtures are preferred. For spin coating alkylated benzenes like xylene and toluene are preferred.

Examples of especially preferred solvents include, without limitation,

dichloromethane, trichloromethane, monochlorobenzene, o-dichlorobenzene, tetrahydrofuran, anisole, morpholine, toluene, o-xylene, m-xylene, p-xylene, 1,4-dioxane, acetone, methylethylketone, 1,2-dichloroethane, 1,1,1-trichloroethane, 1,1,2,2-tetrachloroethane, ethyl acetate, n-butyl acetate, dimethylformamide, dimethylacetamide, dimethylsulfoxide, tetraline, decaline, indane, methyl benzoate, ethyl benzoate, mesitylene and/or mixtures thereof.

The concentration of the polymers in the solution is preferably 0.1 to 10% by weight, more preferably 0.5 to 5% by weight. Optionally, the solution also comprises one or more binders to adjust the rheological properties, as described for example in WO 2005/055248 A1.

After the appropriate mixing and ageing, solutions are evaluated as one of the following categories: complete solution, borderline solution or insoluble. The contour line is drawn to outline the solubility parameter-hydrogen bonding limits dividing solubility and insolubility. 'Complete' solvents falling within the solubility area can be chosen from literature values such as published in "Crowley, J.D., Teague, G.S. Jr and Lowe, J.W. Jr., Journal of Paint Technology, 38, No 496, 296 (1966)". Solvent blends may also be used and can be identified as described in "Solvents, W.H.Ellis, Federation of Societies for Coatings Technology, p9-10, 1986". Such a procedure may lead to a blend of 'non' solvents that will dissolve both the polymers of the present invention, although it is desirable to have at least one true solvent in a blend.

The polymers according to the present invention can also be used in patterned OSC layers in the devices as described above and below. For applications in modern microelectronics it is generally desirable to generate small structures or patterns to reduce cost (more devices/unit area), and power consumption. Patterning of thin layers comprising a polymer according to the present invention can be carried out for example by photolithography, electron beam lithography or laser patterning.

For use as thin layers in electronic or electrooptical devices the polymers, polymer blends or formulations of the present invention may be deposited

by any suitable method. Liquid coating of devices is more desirable than vacuum deposition techniques. Solution deposition methods are especially preferred. The formulations of the present invention enable the use of a number of liquid coating techniques. Preferred deposition techniques include, without limitation, dip coating, spin coating, ink jet printing, letter-press printing, screen printing, doctor blade coating, roller printing, reverse-roller printing, offset lithography printing, flexographic printing, web printing, spray coating, brush coating or pad printing. Ink-jet printing is particularly preferred as it allows high resolution layers and devices to be prepared.

Selected formulations of the present invention may be applied to prefabricated device substrates by ink jet printing or microdispensing. Preferably industrial piezoelectric print heads such as but not limited to those supplied by Aprion, Hitachi-Koki, InkJet Technology, On Target Technology, Picojet, Spectra, Trident, Xaar may be used to apply the organic semiconductor layer to a substrate. Additionally semi-industrial heads such as those manufactured by Brother, Epson, Konica, Seiko Instruments Toshiba TEC or single nozzle microdispensers such as those produced by Microdrop and Microfab may be used.

In order to be applied by ink jet printing or microdispensing, the polymers should be first dissolved in a suitable solvent. Solvents must fulfil the requirements stated above and must not have any detrimental effect on the chosen print head. Additionally, solvents should have boiling points $>100^{\circ}\text{C}$, preferably $>140^{\circ}\text{C}$ and more preferably $>150^{\circ}\text{C}$ in order to prevent operability problems caused by the solution drying out inside the print head. Apart from the solvents mentioned above, suitable solvents include substituted and non-substituted xylene derivatives, di- C_{1-2} -alkyl formamide, substituted and non-substituted anisoles and other phenol-ether derivatives, substituted heterocycles such as substituted pyridines, pyrazines, pyrimidines, pyrrolidinones, substituted and non-substituted N,N -di- C_{1-2} -alkylanilines and other fluorinated or chlorinated aromatics.

A preferred solvent for depositing a polymer according to the present invention by ink jet printing comprises a benzene derivative which has a

benzene ring substituted by one or more substituents wherein the total number of carbon atoms among the one or more substituents is at least three. For example, the benzene derivative may be substituted with a propyl group or three methyl groups, in either case there being at least three carbon atoms in total. Such a solvent enables an ink jet fluid to be formed comprising the solvent with the polymer, which reduces or prevents clogging of the jets and separation of the components during spraying. The solvent(s) may include those selected from the following list of examples: dodecylbenzene, 1-methyl-4-tert-butylbenzene, terpineol limonene, isodurene, terpinolene, cymene, diethylbenzene. The solvent may be a solvent mixture, that is a combination of two or more solvents, each solvent preferably having a boiling point $>100^{\circ}\text{C}$, more preferably $>140^{\circ}\text{C}$. Such solvent(s) also enhance film formation in the layer deposited and reduce defects in the layer.

15

The ink jet fluid (that is mixture of solvent, binder and semiconducting compound) preferably has a viscosity at 20°C of 1-100 mPa's, more preferably 1-50 mPa's and most preferably 1-30 mPa's.

20

The polymers or formulations according to the present invention can additionally comprise one or more further components or additives selected for for example from surface-active compounds, lubricating agents, wetting agents, dispersing agents, hydrophobing agents, adhesive agents, flow improvers, defoaming agents, deaerators, diluents which may be reactive or non-reactive, auxiliaries, colourants, dyes or pigments, sensitizers, stabilizers, nanoparticles or inhibitors.

25

The polymers according to the present invention are useful as charge transport, semiconducting, electrically conducting, photoconducting or light emitting materials in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices. In these devices, the polymers of the present invention are typically applied as thin layers or films.

30

Thus, the present invention also provides the use of the semiconducting polymer, polymer blend, formulation or layer in an electronic device. The formulation may be used as a high mobility semiconducting material in

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various devices and apparatus. The formulation may be used, for example, in the form of a semiconducting layer or film. Accordingly, in another aspect, the present invention provides a semiconducting layer for use in an electronic device, the layer comprising a polymer, polymer blend or
5 formulation according to the invention. The layer or film may be less than about 30 microns. For various electronic device applications, the thickness may be less than about 1 micron thick. The layer may be deposited, for example on a part of an electronic device, by any of the aforementioned solution coating or printing techniques.

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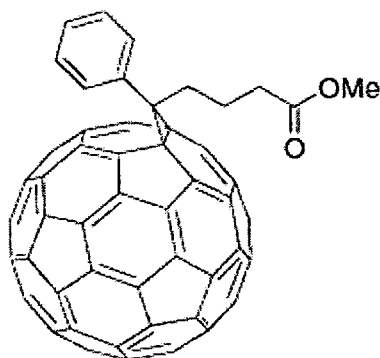
The invention additionally provides an electronic device comprising a polymer, polymer blend, formulation or organic semiconducting layer according to the present invention. Especially preferred devices are OFETs, TFTs, ICs, logic circuits, capacitors, RFID tags, OLEDs, OLETs,
15 OPEDs, OPVs, solar cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, sensor devices, charge injection layers, Schottky diodes, planarising layers, antistatic films, conducting substrates and conducting patterns.

20

Especially preferred electronic device are OFETs, OLEDs and OPV devices, in particular bulk heterojunction (BHJ) OPV devices. In an OFET, for example, the active semiconductor channel between the drain and source may comprise the layer of the invention. As another example, in an
25 OLED device, the charge (hole or electron) injection or transport layer may comprise the layer of the invention.

For use in OPV devices the polymer according to the present invention is preferably used in a formulation that comprises or contains, more preferably consists essentially of, very preferably exclusively of, a p-type
30 (electron donor) semiconductor and an n-type (electron acceptor) semiconductor. The p-type semiconductor is constituted by a polymer according to the present invention. The n-type semiconductor can be an inorganic material such as zinc oxide or cadmium selenide, or an organic material such as a fullerene derivate, for example (6,6)-phenyl-butyric acid
35 methyl ester derivatized methano C₆₀ fullerene, also known as "PCBM" or

"C₆₀PCBM", as disclosed for example in G. Yu, J. Gao, J.C. Hummelen, F. Wudl, A.J. Heeger, *Science* 1995, Vol. 270, p. 1789 ff and having the structure shown below, or an structural analogous compound with e.g. a C₇₀ fullerene group (C₇₀PCBM), or a polymer (see for example Coakley, K. M. and McGehee, M. D. *Chem. Mater.* 2004, 16, 4533).

C₆₀PCBM

A preferred material of this type is a blend or mixture of a polymer according to the present invention with a C₆₀ or C₇₀ fullerene or modified fullerene like PCBM. Preferably the ratio polymer:fullerene is from 2:1 to 1:2 by weight, more preferably from 1.2:1 to 1:1.2 by weight, most preferably 1:1 by weight. For the blended mixture, an optional annealing step may be necessary to optimize blend morphology and consequently OPV device performance.

The OPV device can for example be of any type known from the literature [see e.g. Waldauf et al., *Appl. Phys. Lett.* **89**, 233517 (2006)].

A first preferred OPV device according to the invention comprises:

- a low work function electrode (11) (for example a metal, such as aluminum), and a high work function electrode (12) (for example ITO), one of which is transparent,
- a layer (13) (also referred to as "active layer") comprising a hole transporting material and an electron transporting material, preferably selected from OSC materials, situated between the electrodes (11,12); the active layer can exist for example as a bilayer or two distinct layers or blend or mixture of p-type and n-type semiconductor, forming a bulk heterjunction (BHJ) (see for example Coakley, K. M. and McGehee, M.

D. *Chem. Mater.* **2004**, *16*, 4533),

- an optional conducting polymer layer (14), for example comprising a blend of PEDOT:PSS (poly(3,4-ethylenedioxythiophene): poly(styrenesulfonate)), situated between the active layer (13) and the high work function electrode (12), to modify the work function of the high work function electrode to provide an ohmic contact for holes,
- an optional coating (15) (for example of LiF) on the side of the low workfunction electrode (11) facing the active layer (13), to provide an ohmic contact for electrons.

A second preferred OPV device according to the invention is an inverted OPV device and comprises:

- a low work function electrode (21) (for example a metal, such as gold), and a high work function electrode (22) (for example ITO), one of which is transparent,
- a layer (23) (also referred to as "active layer") comprising a hole transporting material and an electron transporting material, preferably selected from OSC materials, situated between the electrodes (21,22); the active layer can exist for example as a bilayer or two distinct layers or blend or mixture of p-type and n-type semiconductor, forming a BHJ,
- an optional conducting polymer layer (24), for example comprising a blend of PEDOT:PSS, situated between the active layer (23) and the low work function electrode (21) to provide an ohmic contact for electrons,
- an optional coating (25) (for example of TiO_x) on the side of the high workfunction electrode (22) facing the active layer (23), to provide an ohmic contact for holes.

In the OPV devices of the present invention the p-type and n-type semiconductor materials are preferably selected from the materials, like the polymer/fullerene systems, as described above. If the bilayer is a blend an optional annealing step may be necessary to optimize device performance.

The compound, formulation and layer of the present invention are also suitable for use in an OFET as the semiconducting channel. Accordingly,

the invention also provides an OFET comprising a gate electrode, an insulating (or gate insulator) layer, a source electrode, a drain electrode and an organic semiconducting channel connecting the source and drain electrodes, wherein the organic semiconducting channel comprises a polymer, polymer blend, formulation or organic semiconducting layer according to the present invention. Other features of the OFET are well known to those skilled in the art.

OFETs where an OSC material is arranged as a thin film between a gate dielectric and a drain and a source electrode, are generally known, and are described for example in US 5,892,244, US 5,998,804, US 6,723,394 and in the references cited in the background section. Due to the advantages, like low cost production using the solubility properties of the compounds according to the invention and thus the processibility of large surfaces, preferred applications of these FETs are such as integrated circuitry, TFT displays and security applications.

The gate, source and drain electrodes and the insulating and semiconducting layer in the OFET device may be arranged in any sequence, provided that the source and drain electrode are separated from the gate electrode by the insulating layer, the gate electrode and the semiconductor layer both contact the insulating layer, and the source electrode and the drain electrode both contact the semiconducting layer.

An OFET device according to the present invention preferably comprises:

- a source electrode,
- a drain electrode,
- a gate electrode,
- a semiconducting layer,
- one or more gate insulator layers,
- optionally a substrate.

wherein the semiconductor layer preferably comprises a polymer, polymer blend or formulation as described above and below.

The OFET device can be a top gate device or a bottom gate device.

Suitable structures and manufacturing methods of an OFET device are known to the skilled in the art and are described in the literature, for example in US 2007/0102696 A1.

5 The gate insulator layer preferably comprises a fluoropolymer, like e.g. the commercially available Cytop 809M® or Cytop 107M® (from Asahi Glass). Preferably the gate insulator layer is deposited, e.g. by spin-coating, doctor blading, wire bar coating, spray or dip coating or other known
10 methods, from a formulation comprising an insulator material and one or more solvents with one or more fluoro atoms (fluorosolvents), preferably a perfluorosolvent. A suitable perfluorosolvent is e.g. FC75® (available from Acros, catalogue number 12380). Other suitable fluoropolymers and fluorosolvents are known in prior art, like for example the
15 perfluoropolymers Teflon AF® 1600 or 2400 (from DuPont) or Fluoropel® (from Cytonix) or the perfluorosolvent FC 43® (Acros, No. 12377). Especially preferred are organic dielectric materials having a low permittivity (or dielectric constant) from 1.0 to 5.0, very preferably from 1.8 to 4.0 ("low *k* materials"), as disclosed for example in US 2007/0102696
20 A1 or US 7,095,044.

20 In security applications, OFETs and other devices with semiconducting materials according to the present invention, like transistors or diodes, can be used for RFID tags or security markings to authenticate and prevent counterfeiting of documents of value like banknotes, credit cards or ID
25 cards, national ID documents, licenses or any product with monetary value, like stamps, tickets, shares, cheques etc..

Alternatively, the materials according to the invention can be used in OLEDs, e.g. as the active display material in a flat panel display
30 applications, or as backlight of a flat panel display like e.g. a liquid crystal display. Common OLEDs are realized using multilayer structures. An emission layer is generally sandwiched between one or more electron-transport and/ or hole-transport layers. By applying an electric voltage electrons and holes as charge carriers move towards the emission layer
35 where their recombination leads to the excitation and hence luminescence of the lumophor units contained in the emission layer. The inventive

5 compounds, materials and films may be employed in one or more of the charge transport layers and/ or in the emission layer, corresponding to their electrical and/ or optical properties. Furthermore their use within the emission layer is especially advantageous, if the compounds, materials and films according to the invention show electroluminescent properties themselves or comprise electroluminescent groups or compounds. The selection, characterization as well as the processing of suitable monomeric, oligomeric and polymeric compounds or materials for the use in OLEDs is generally known by a person skilled in the art, see, e.g., 10 Meerholz, Synthetic Materials, 111-112, 2000, 31-34, Alcalá, J. Appl. Phys., 88, 2000, 7124-7128 and the literature cited therein.

15 According to another use, the materials according to this invention, especially those showing photoluminescent properties, may be employed as materials of light sources, e.g. in display devices, as described in EP 0 889 350 A1 or by C. Weder et al., Science, 279, 1998, 835-837.

20 A further aspect of the invention relates to both the oxidised and reduced form of the compounds according to this invention. Either loss or gain of electrons results in formation of a highly delocalised ionic form, which is of high conductivity. This can occur on exposure to common dopants. Suitable dopants and methods of doping are known to those skilled in the art, e.g. from EP 0 528 662, US 5,198,153 or WO 96/21659.

25 The doping process typically implies treatment of the semiconductor material with an oxidating or reducing agent in a redox reaction to form delocalised ionic centres in the material, with the corresponding counterions derived from the applied dopants. Suitable doping methods comprise for example exposure to a doping vapor in the atmospheric 30 pressure or at a reduced pressure, electrochemical doping in a solution containing a dopant, bringing a dopant into contact with the semiconductor material to be thermally diffused, and ion-implantation of the dopant into the semiconductor material.

35 When electrons are used as carriers, suitable dopants are for example halogens (e.g., I₂, Cl₂, Br₂, ICl, ICl₃, IBr and IF), Lewis acids (e.g., PF₅,

AsF₅, SbF₅, BF₃, BCl₃, SbCl₅, BBr₃ and SO₃), protonic acids, organic acids, or amino acids (e.g., HF, HCl, HNO₃, H₂SO₄, HClO₄, FSO₃H and ClSO₃H), transition metal compounds (e.g., FeCl₃, FeOCl, Fe(ClO₄)₃, Fe(4-CH₃C₆H₄SO₃)₃, TiCl₄, ZrCl₄, HfCl₄, NbF₅, NbCl₅, TaCl₅, MoF₅, MoCl₅, WF₅, WCl₆, UF₆ and LnCl₃ (wherein Ln is a lanthanoid), anions (e.g., Cl⁻, Br⁻, I⁻, I₃⁻, HSO₄⁻, SO₄²⁻, NO₃⁻, ClO₄⁻, BF₄⁻, PF₆⁻, AsF₆⁻, SbF₆⁻, FeCl₄⁻, Fe(CN)₆³⁻, and anions of various sulfonic acids, such as aryl-SO₃⁻). When holes are used as carriers, examples of dopants are cations (e.g., H⁺, Li⁺, Na⁺, K⁺, Rb⁺ and Cs⁺), alkali metals (e.g., Li, Na, K, Rb, and Cs), alkaline-earth metals (e.g., Ca, Sr, and Ba), O₂, XeOF₄, (NO₂⁺) (SbF₆⁻), (NO₂⁺) (SbCl₆⁻), (NO₂⁺) (BF₄⁻), AgClO₄, H₂IrCl₆, La(NO₃)₃ · 6H₂O, FSO₂OOSO₂F, Eu, acetylcholine, R₄N⁺ (R is an alkyl group), R₄P⁺ (R is an alkyl group), R₆As⁺ (R is an alkyl group), and R₃S⁺ (R is an alkyl group).

The conducting form of the compounds of the present invention can be used as an organic "metal" in applications including, but not limited to, charge injection layers and ITO planarising layers in OLED applications, films for flat panel displays and touch screens, antistatic films, printed conductive substrates, patterns or tracts in electronic applications such as printed circuit boards and condensers.

The compounds and formulations according to the present invention may also be suitable for use in organic plasmon-emitting diodes (OPEDs), as described for example in Koller et al., Nature Photonics 2008 (published online September 28, 2008).

According to another use, the materials according to the present invention can be used alone or together with other materials in or as alignment layers in LCD or OLED devices, as described for example in US 2003/0021913. The use of charge transport compounds according to the present invention can increase the electrical conductivity of the alignment layer. When used in an LCD, this increased electrical conductivity can reduce adverse residual dc effects in the switchable LCD cell and suppress image sticking or, for example in ferroelectric LCDs, reduce the residual charge produced by the switching of the spontaneous polarisation charge of the ferroelectric LCs. When used in an OLED device comprising

a light emitting material provided onto the alignment layer, this increased electrical conductivity can enhance the electroluminescence of the light emitting material. The compounds or materials according to the present invention having mesogenic or liquid crystalline properties can form oriented anisotropic films as described above, which are especially useful as alignment layers to induce or enhance alignment in a liquid crystal medium provided onto said anisotropic film. The materials according to the present invention may also be combined with photoisomerisable compounds and/or chromophores for use in or as photoalignment layers, as described in US 2003/0021913.

According to another use the materials according to the present invention, especially their water-soluble derivatives (for example with polar or ionic side groups) or ionically doped forms, can be employed as chemical sensors or materials for detecting and discriminating DNA sequences. Such uses are described for example in L. Chen, D. W. McBranch, H. Wang, R. Helgeson, F. Wudl and D. G. Whitten, Proc. Natl. Acad. Sci. U.S.A. 1999, **96**, 12287; D. Wang, X. Gong, P. S. Heeger, F. Rininsland, G. C. Bazan and A. J. Heeger, Proc. Natl. Acad. Sci. U.S.A. 2002, **99**, 49; N. DiCesare, M. R. Pinot, K. S. Schanze and J. R. Lakowicz, Langmuir 2002, **18**, 7785; D. T. McQuade, A. E. Pullen, T. M. Swager, Chem. Rev. 2000, **100**, 2537.

Unless the context clearly indicates otherwise, as used herein plural forms of the terms herein are to be construed as including the singular form and vice versa.

Throughout the description and claims of this specification, the words "comprise" and "contain" and variations of the words, for example "comprising" and "comprises", mean "including but not limited to", and are not intended to (and do not) exclude other components.

It will be appreciated that variations to the foregoing embodiments of the invention can be made while still falling within the scope of the invention. Each feature disclosed in this specification, unless stated otherwise, may be replaced by alternative features serving the same, equivalent or similar

purpose. Thus, unless stated otherwise, each feature disclosed is one example only of a generic series of equivalent or similar features.

5 All of the features disclosed in this specification may be combined in any combination, except combinations where at least some of such features and/or steps are mutually exclusive. In particular, the preferred features of the invention are applicable to all aspects of the invention and may be used in any combination. Likewise, features described in non-essential combinations may be used separately (not in combination).

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It will be appreciated that many of the features described above, particularly of the preferred embodiments, are inventive in their own right and not just as part of an embodiment of the present invention. Independent protection may be sought for these features in addition to or
15 alternative to any invention presently claimed.

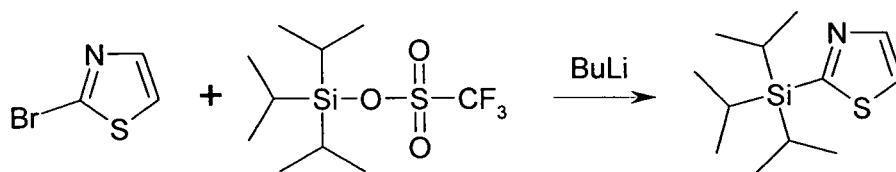
The invention will now be described in more detail by reference to the following examples, which are illustrative only and do not limit the scope of the invention.

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Example 1

1.1 2-Triisopropylsilanyl-thiazole

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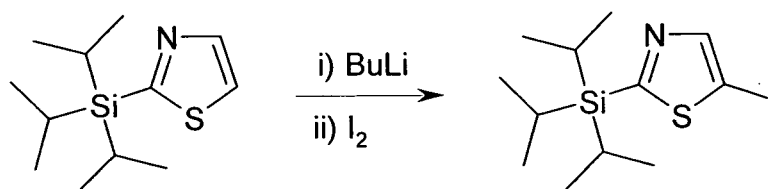
To a solution of 2-bromo-thiazole (20.5 cm³, 230 mmol) in anhydrous tetrahydrofuran (800 cm³) at -78 °C is added *n*-butyllithium (2.5 M in hexanes, 100 cm³, 250 mmol) dropwise over 7 minutes. After addition, the mixture is stirred for 1 hour at -78 °C. Triisopropylsilyltriflate (79.5 cm³, 300 mmol) is added dropwise and the reaction mixture stirred at -78 °C for 1
35 hour and then allowed to warm to 23 °C. The reaction mixture is poured into water (500 cm³) and extracted with diethyl ether (3 x 250 cm³). The

combined organic layers washed with aqueous sodium hydrogen carbonate solution, brine and dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo* to give a dark brown oil. The residue is distilled under vacuum (80 °C, 0.5 mBar) to give 2-

5 triisopropylsilanyl-thiazole as a pale yellow oil (30 g, 55%). ¹H NMR (300 MHz, CDCl₃) 1.12 - 1.17 (18H, m, CH₃), 1.39 - 1.53 (3H, m, CH), 7.55 (1H, d, ArH, J 3.0), 8.17 (1H, d, ArH, J 3.0).

1.2 5-Iodo-2-triisopropylsilanyl-thiazole

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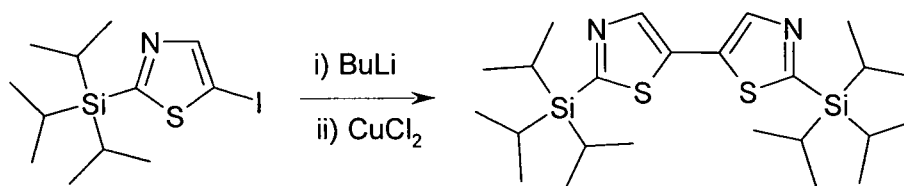
To a solution of 2-triisopropylsilanyl-thiazole (55 g, 230 mmol) in anhydrous tetrahydrofuran (1000 cm³) at -78 °C is added *n*-butyllithium (2.5 M in hexanes, 109 cm³, 270 mmol) dropwise. After addition, the mixture is stirred for 2 hours at -78 °C. 1,2-Diiodoethane (77 g, 270 mmol) is added in one go and the reaction mixture stirred at -78 °C for 1 hour and then allowed to warm to 23 °C over 17 hours. The reaction mixture is diluted with ethyl acetate (500 cm³) and washed with aqueous sodium hydrogen carbonate solution, brine and dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo* to give a dark brown oil.

25 The residue is purified by column chromatography (40-60 petrol to 1:1 40-60 petrol:dichloromethane) to give 5-iodo-2-triisopropylsilanyl-thiazole as a very pale yellow solid (65 g, 78%). ¹H NMR (300 MHz, CDCl₃) 1.10 - 1.16 (18H, m, CH₃), 1.34 - 1.48 (3H, m, CH), 8.10 (1H, s).

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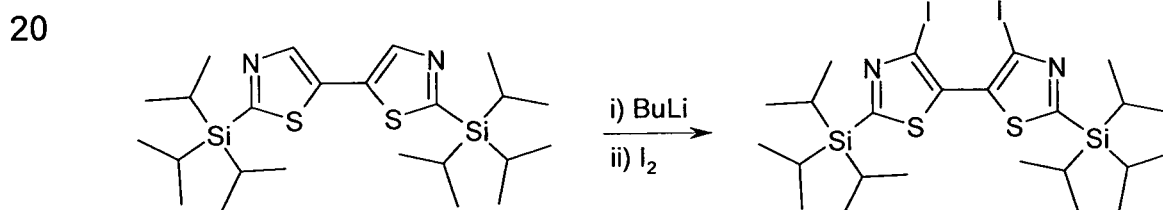
1.3 2,2'-Bis-triisopropylsilanyl-[5,5']bithiazolyI

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To a solution of 5-iodo-2-triisopropylsilyl-thiazole (50 g, 136 mmol) in anhydrous diethyl ether (2000 cm³) at -78 °C is added *n*-butyllithium (2.5 M in hexanes, 65.3 cm³, 163 mmol) dropwise over 30 minutes. After addition, the mixture is stirred for 2 hours at -78 °C. Anhydrous copper (II) chloride (22.0 g, 163 mmol) is added in one go and the reaction mixture stirred at -78 °C for 1 hour and then allowed to warm to 23 °C over 17 hours. The reaction mixture is poured into aqueous hydrochloric acid (1 M, 1000 cm³) and the organics extracted with ethyl acetate (3 x 500 cm³). The combined organic extracts washed with brine and dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo* to give an oily residue which is triturated with ethanol to form a suspension. The solid is collected by filtration and dried under vacuum to give 2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl as a pale yellow solid (15 g, 46%). ¹H NMR (300 MHz, CDCl₃) 1.12 - 1.20 (36H, m, CH₃), 1.48 - 1.58 (6H, m, CH), 8.20 (2H, s).

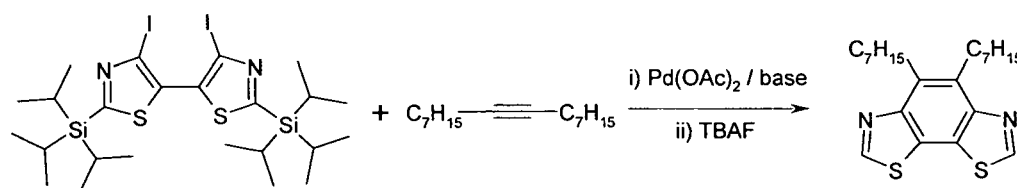
1.4 4,4'-Diiodo-2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl



To *n*-butyllithium (2.5 M in hexanes, 25.0 cm³, 62 mmol) at -40 °C is added a solution of 2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl (10 g, 21 mmol) in anhydrous tetrahydrofuran (800 cm³). After addition, the reaction mixture is stirred at -40 °C for 30 minutes. Lithium diisopropylamide (2.0 M in tetrahydrofuran/heptanes/ethylbenzene, 62.4 cm³, 125 mmol) is added dropwise and then the reaction mixture is stirred at -40 °C for 1 hour. To the reaction mixture is then added dropwise a solution of diiodoethane (35.2 g, 125 mmol) in anhydrous tetrahydrofuran (200 cm³). After addition, the mixture is stirred for 1 hour at -40 °C and then allowed to warm to 23 °C over 17 hours. The reaction mixture is poured into water (300 cm³) and the mixture concentrated *in vacuo*. The organics are extracted with ethyl

acetate (3 x 500 cm³) and the combined extracts washed with aqueous sodium sulphate, brine and dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo* to give a brown oily residue. The crude is purified by column chromatography (40-60 petrol to 3:2 40-60 petrol:dichloromethane) to give 4,4'-diiodo-2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl as a pale yellow solid (6.12 g, 40%). ¹H NMR (300 MHz, CDCl₃) 1.11 - 1.21 (36H, m, CH₃), 1.38 - 1.55 (6H, m, CH).

1.5 4,5-Diheptyl-benzo[1,2-*d*;4,3-*d'*]bisthiazole



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A mixture of 4,4'-diiodo-2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl (1.0 g, 1.4 mmol), palladium (II) acetate (31 mg, 0.14 mmol), anhydrous *N,N*-dimethylformamide (6 cm³), hexadec-8-yne (911 mg, 4.1 mmol) and *N,N*-dicyclohexylmethylamine (0.88 cm³, 4.1 mmol) is degassed for 10 minutes. The mixture is then heated at 200 °C in a microwave reactor (Initiator, Biotage AB) for 60 minutes. The mixture is allowed to cool and poured into aqueous hydrochloric acid (2 M, 50 cm³) and the organics extracted with dichloromethane (2 x 50 cm³). The combined extracts dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo*. The crude is purified by column chromatography (40-60 petrol to dichloromethane). The purified material is deprotected by stirring with tetrabutylammonium fluoride trihydrate (1.5 g, 4.8 mmol) and tetrahydrofuran (40 cm³) at 70 °C for 1 hour. The mixture is allowed to cool, water (50 cm³) added and the organics extracted with dichloromethane (2 x 100 cm³). The combined extracts dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo*. The crude is purified by column chromatography (40-60 petrol to dichloromethane) to give 4,5-diheptyl-benzo[1,2-*d*;4,3-*d'*]bisthiazole as a pale yellow solid (185 mg, 35%). ¹H NMR (300 MHz, CDCl₃) 0.84 - 0.93 (6H, m, CH₃), 1.24 - 1.44 (12H, m, CH₂), 1.45 - 1.57 (4H, m, CH₂), 1.65 - 1.80 (4H, m, CH₂), 3.25 - 3.35 (4H, m, CH₂), 9.00 (2H, s, ArH); ¹³C NMR

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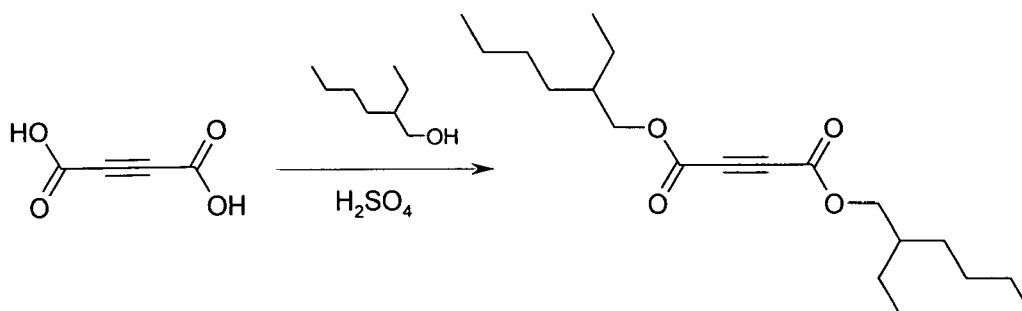
(300 MHz, CDCl₃) 14.2, 22.7, 29.3, 29.7, 30.2, 31.6, 31.9, 124.0, 134.1, 151.2, 151.8.

Example 2

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2.1 But-2-yne-1,4-dioic acid bis-(2-ethyl-hexyl) ester

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A mixture of acetylenedicarboxylic acid (25.0 g, 219 mmol), ethylhexanol (103 cm³, 660 mmol), anhydrous toluene (100 cm³) and sulfuric acid (10 cm³) is heated at reflux under Dean-Stark conditions for 17 hours. The mixture is allowed to cool, brine (200 cm³) added and the product extracted with ether (2 x 250 cm³). The combined organic extracts dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo* to give a brown oil. The residue is distilled under vacuum (144 °C, 0.07 mBar) to give but-2-yne-1,4-dioic acid bis-(2-ethyl-hexyl) ester as a pale yellow oil (31.9 g, 36%). ¹H NMR (300 MHz, CDCl₃) 0.85 - 0.95 (12H, m, CH₃), 1.23 - 1.41 (16H, m, CH₂), 1.57 - 1.70 (2H, m, CH), 4.11 - 4.21 (4H, m, OCH₂); ¹³C NMR (300 MHz, CDCl₃) 10.9, 14.0, 22.9, 23.5, 28.8, 30.1, 38.6, 69.2, 74.7, 152.1.

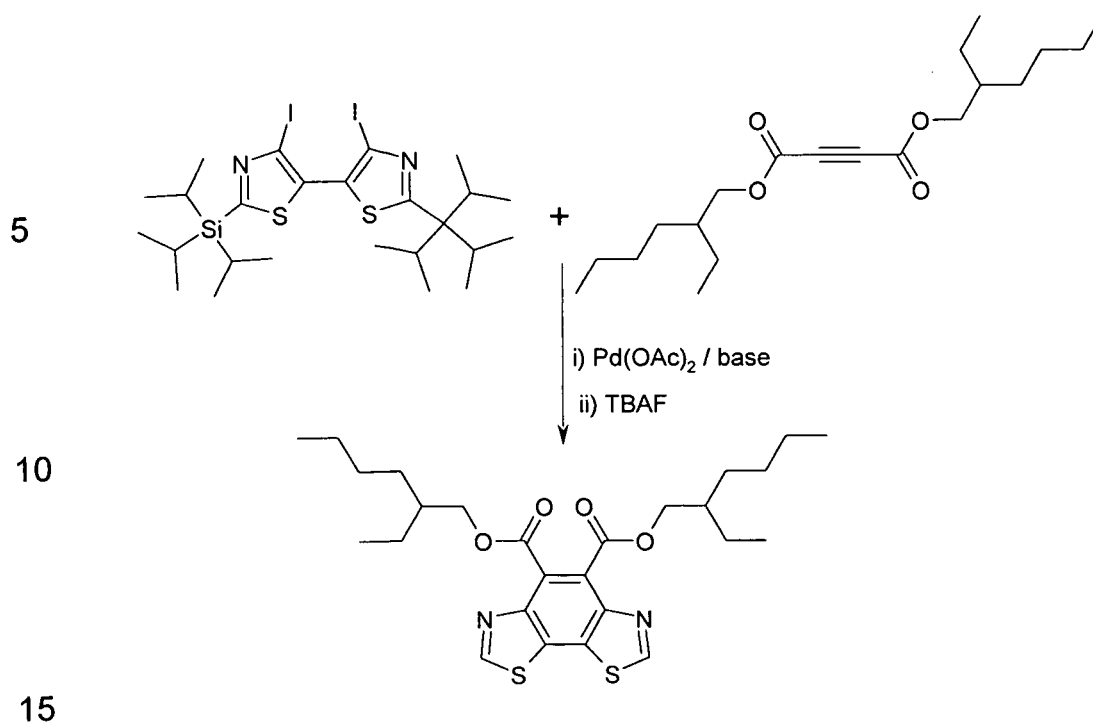
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2.2 Benzo[1,2-*d*:4,3-*d'*]bisthiazole-4,5-dicarboxylic acid bis-(2-ethyl-hexyl) ester

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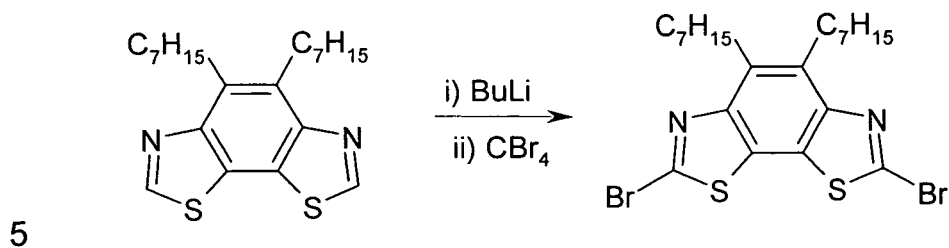
20 A mixture of 4,4'-diiodo-2,2'-bis-triisopropylsilyl-[5,5']bithiazolyl (250 mg, 0.34 mmol), palladium (II) acetate (8 mg, 0.03 mmol), anhydrous *N,N*-dimethylformamide (1.5 cm³), but-2-yne-1,4-diol bis-(2-ethyl-hexyl) ester (346 mg, 1.0 mmol) and *N,N*-dicyclohexylmethylamine (0.22 cm³, 1.0 mmol) is degassed for 10 minutes. The mixture is then heated at 200 °C in a microwave reactor for 60 minutes. To the mixture is added tetrabutylammonium fluoride trihydrate (0.3 g, 0.95 mmol) and the reaction mixture heated at 70 °C for 1 hour. The mixture is allowed to cool, water (30 cm³) added and the organics extracted with dichloromethane (2 x 50 cm³). The combined extracts dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo*. The crude is purified by column chromatography (40-60 petrol to dichloromethane) to give benzo[1,2-*d*;4,3-*d'*]bisthiazole-4,5-dicarboxylic acid bis-(2-ethyl-hexyl) ester as a pale yellow solid (18 mg, 9%). ¹H NMR (300 MHz, CDCl₃) 0.78 - 1.89 (30H, m, CH, CH₂ and CH₃), 4.31 - 4.44 (4H, m, OCH₂), 9.17 (2H, s, ArH).

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Example 3

35 3.1 2,7-Dibromo-4,5-diheptyl-benzo[1,2-*d*;4,3-*d'*]bisthiazole



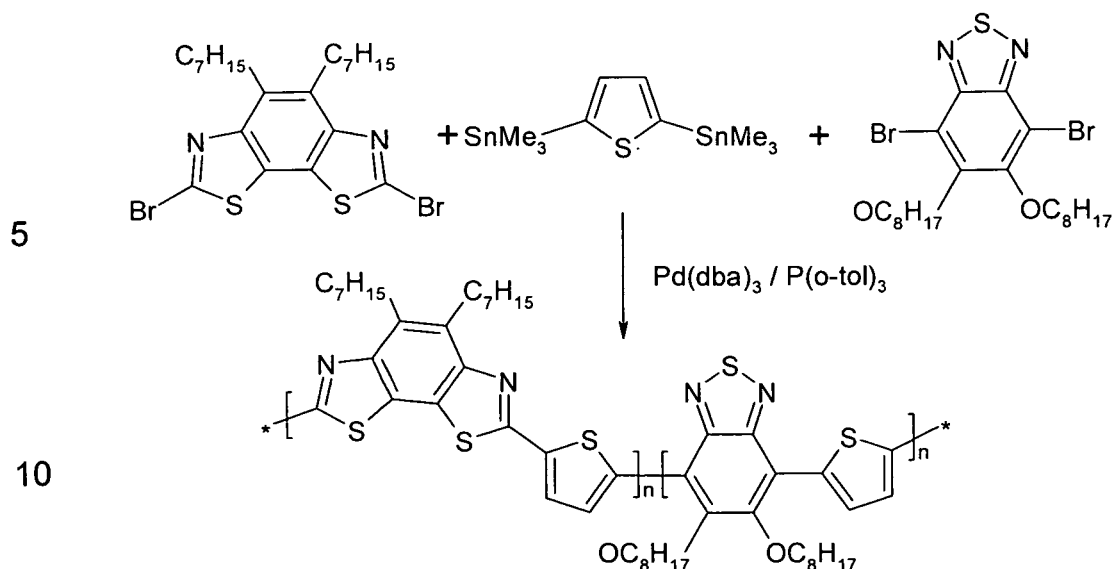
To a solution of 4,5-diheptyl-benzo[1,2-d;4,3-d']bisthiazole (50 mg, 0.13 mmol) in anhydrous tetrahydrofuran (5 cm³) at -78 °C is added dropwise *n*-butyllithium (1.6 M in hexanes, 0.18 cm³, 0.28 mmol). After addition, the mixture is stirred at -78 °C for 15 minutes and carbon tetrabromide (102 mg, 0.31 mmol) is added in one go. The mixture is then stirred at -78 °C for 10 minutes. Methanol (20 cm³) is added and the reaction mixture stirred at 23 °C for 30 minutes. Water (50 cm³) added and the organics extracted with dichloromethane (2 x 50 cm³). The combined extracts dried over anhydrous magnesium sulfate, filtered and the solvent removed *in vacuo*. The crude is purified by column chromatography (40-60 petrol to dichloromethane) followed by precipitation from dichloromethane into methanol to give 2,7-dibromo-4,5-diheptyl-benzo[1,2-*d'*;4,3-*d'*]bisthiazole as an off-white solid (42 mg, 60%). ¹H NMR (300 MHz, CDCl₃) 0.83 - 0.94 (6H, m, CH₃), 1.22 - 1.51 (16H, m, CH₂), 1.59 - 1.73 (4H, m, CH₂), 3.12 - 3.22 (4H, m, CH₂); ¹³C NMR (300 MHz, CDCl₃) 14.2, 22.7, 29.2, 29.3, 29.9, 31.3, 31.9, 126.1, 134.2, 135.4, 150.7.

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3.2 Poly{4,7-5,6-bis-octyloxy-benzo[1,2,5]thiadiazole}-co-{2,5-thienyl}-co-{2,7-4,5-diheptyl-benzo[1,2-*d'*;4,3-*d'*]bisthiazole}

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15 A mixture of 2,7-dibromo-4,5-diheptyl-benzo[1,2-*d'*;4,3-*d'*]bisthiazole (91.4 mg, 0.167 mmol), 2,5-bis-trimethylstannanyl-thiophene (137.1 mg, 0.335 mmol), 4,7-dibromo-5,6-bis-octyloxy-benzo[1,2,5]thiadiazole (92.1 mg, 0.167 mmol), tris(dibenzyl-ideneacetone)dipalladium(0) (6.1 mg, 0.07 mmol), tri(*o*-tolyl)phosphine (8.1 mg, 0.03 mmol) and chlorobenzene (4.5 cm³) is degassed for 10 minutes. The mixture is then heated at 170 °C in a microwave reactor (Initiator, Biotage AB) for 30 minutes. The mixture is allowed to cool and poured into stirring methanol (100 cm³) and the precipitate stirred for 30 minutes. The solid is then collected by filtration, washed with methanol (100 cm³) to give a black solid. The crude polymer is washed via Soxhlet extraction with acetone, methanol, 40-60 petrol and chloroform. The chloroform extract is precipitated into stirred methanol (400 cm³). The polymer collected by filtration and dried under vacuum to give poly{4,7-5,6-bis-octyloxy-benzo[1,2,5]thiadiazole}-co-{2,5-thienyl}-co-{2,7-4,5-diheptyl-benzo[1,2-*d'*;4,3-*d'*]bisthiazole} as a black solid (80 mg, 51%). GPC (trichlorobenzene, 140 °C) M_n = 3,700 g/mol, M_w = 5,900 g/mol, pd = 1.60.

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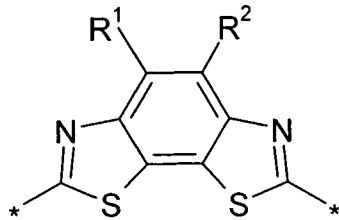
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Patent Claims

1. Polymer comprising one or more identical or different repeating units containing a moiety of formula I

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I

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wherein an asterisk indicates a link to a neighbored group, and R^1 and R^2 are, each independently of one another, H, halogen, or an optionally substituted carbyl or hydrocarbyl group.

15

2. Polymer according to claim 1, wherein R^1 and R^2 in formula I are selected from H, straight-chain, branched or cyclic alkyl with 1 to 35 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -C(O)-, -C(O)-O-, -O-C(O)-, -O-C(O)-O-, - $CR^0=CR^{00}$ - or - $C\equiv C$ - and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN, or denote aryl, heteroaryl, aryloxy, heteroaryloxy, arylcarbonyl, heteroarylcarbonyl, arylcarbonyloxy, heteroarylcarbonyloxy, aryloxycarbonyl or heteroaryloxycarbonyl having 4 to 30 ring atoms that is unsubstituted or substituted by one or more non-aromatic groups R^3 , wherein

20

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R^3 is on each occurrence identically or differently F, Br, Cl, -CN, -NC, -NCO, -NCS, -OCN, -SCN, -C(O)NR⁰R⁰⁰, -C(O)X⁰, -C(O)R⁰, -NH₂, -NR⁰R⁰⁰, -SH, -SR⁰, -SO₃H, -SO₂R⁰, -OH, -NO₂, -CF₃, -SF₅, optionally substituted silyl, carbyl or hydrocarbyl with 1 to 40 C atoms that is optionally substituted and optionally comprises one or more hetero atoms, or P-Sp-,

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R^0 and R^{00} are independently of each other H or optionally substituted C₁₋₄₀ carbyl or hydrocarbyl,

P is a polymerisable or crosslinkable group,

Sp is a spacer group or a single bond, and

5 X⁰ is halogen.

3. Polymer according to claim 1 or 2, which is selected of formula II



wherein

U is on each occurrence identically or differently a moiety of formula I as defined in claim 1,

15

Ar¹, Ar², Ar³ are, on each occurrence identically or differently, and independently of each other, aryl or heteroaryl that is optionally substituted, preferably by one or more groups R³ as defined in claim 2, and one or both of Ar¹ and Ar² may also denote a single bond,

20

Y¹ and Y² are independently of each other H, F, Cl or CN,

x is on each occurrence identically or differently 0, 1 or 2, wherein in at least one repeating unit, i.e. in at least one unit $-(Ar^1-U-Ar^2)_x-(Ar^3)_y-$, x is 1,

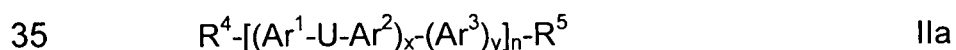
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y is on each occurrence identically or differently 0, 1 or 2,

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n is an integer > 1.

4. Polymer according to one or more of claims 1 to 3, which is selected of formula IIa



wherein U, Ar¹⁻³, n, x and y have the meanings of claim 3, and

5 R⁴ and R⁵ have independently of each other one of the meanings of R³ in claim 2, or denote -CH₂Cl, -CHO, -CH=CH₂, -SiR'R''R''', -SiX'X''R', -SiR'R''X', -SnR'R''R''', -BR'R'', -B(OR')(OR''), -B(OH)₂, O-SO₂-R', -ZnX', -C≡CH, -C≡C-SiR'R''R''', or P-Sp-, wherein P and Sp are as defined above, and R', R'' and R''' have independently of each other one of the meanings of R⁰ as defined in claim 2, and two of R', R'' and R''' may also form a ring together with the hetero atom to which they are attached, and X' and X'' are halogen atoms.

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5. Polymer according to claim 3 or 4, wherein Ar¹ and Ar² are independently of each other selected from the group consisting of, thiophene-2,5-diyl, thiazole-2,5-diyl, selenophene-2,5-diyl, furan-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl, thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, and selenopheno[2,3-b]thiophene-2,5-diyl, all of which are unsubstituted, or mono- or polysubstituted with R³ as defined in claim 2, and one of Ar¹ and Ar² may also denote a single bond.

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6. Polymer according to one or more of claims 3 to 5, wherein Ar³ is, on each occurrence identically or differently, selected from the group consisting of 1,4-phenylene, thiophene-2,5-diyl, selenophene-2,5-diyl, thieno[3,2-b]thiophene-2,5-diyl, thieno[2,3-b]thiophene-2,5-diyl, selenopheno[3,2-b]selenophene-2,5-diyl, selenopheno[2,3-b]selenophene-2,5-diyl, selenopheno[3,2-b]thiophene-2,5-diyl, selenopheno[2,3-b]thiophene-2,5-diyl, benzo[1,2-b:4,5-b']di-thiophene-2,6-diyl, 2,2-dithiophene, 2,2-diselenophene, dithieno[3,2-b:2',3'-d]silole-5,5-diyl, 4*H*-cyclopenta[2,1-b:3,4-b']dithiophene-2,6-diyl, carbazole-2,7-diyl, fluorene-2,7-diyl, indaceno[1,2-b:5,6-b']di-thiophene-2,7-diyl, benzo[1'',2'':4,5;4'',5'':4',5'] bis(silolo[3,2-b:3',2'-b']thiophene)-2,7-diyl, phenanthro[1,10,9,8-c,d,e,f,g]carbazole-2,7-diyl, benzo[2,1,3]thiadiazole-4,7-diyl, benzo[2,1,3]selenadiazole-4,7-diyl, benzo[2,1,3]oxa-

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5 diazole-4,7-diyl, 2H-benzotriazole-4,7-diyl, thieno[3,4-b]pyrazine-2,5-diyl, quinoxaline-5,8-diyl, thieno[3,4-b]thiophene-4,6-diyl, thieno[3,4-b]thiophene-6,4-diyl, 3,6-di-thien-2-yl-pyrrolo[3,4-c]pyrrole-1,4-dione, or [1,3]thiazolo[5,4-d][1,3]thiazole-2,5-diyl, thieno[2,1,3]thiadiazole-2,5-diyl, 2-thia-1,3,5,8-tetraaza-cyclopenta[b]naphthalene-4,9-diyl, thieno[3,4-c]pyrrole-4,6-dione-1,3-diyl, benzo[lmn][3,8]phenanthroline-1,3,6,8-tetraone-4,9-diyl, all of which are unsubstituted, or mono- or polysubstituted, preferably with R¹, R² or R³ as defined in claim 1 and 2.

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7. Polymer according to one or more of claims 1 to 6, wherein R¹ and/or R² are selected from the following groups:

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a) the group consisting of primary alkyl or alkoxy with 1 to 30 C atoms, secondary alkyl or alkoxy with 3 to 30 C atoms, and tertiary alkyl or alkoxy with 4 to 30 C atoms, wherein in all these groups one or more H atoms are optionally replaced by F,

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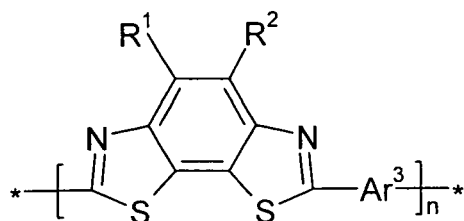
b) the group consisting of -C(O)-R⁶, -C(O)-O-R⁶, -O-C(O)-R⁶, wherein R⁶ is straight-chain, branched or cyclic alkyl with 1 to 30 C atoms, in which one or more non-adjacent C atoms are optionally replaced by -O-, -S-, -C(O)-, -C(O)-O-, -O-C(O)-, -O-C(O)-O-, -CR⁰=CR⁰⁰- or -C≡C- and in which one or more H atoms are optionally replaced by F, Cl, Br, I or CN,

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c) the group consisting of aryl, aryloxy, heteroaryl and heteroaryloxy that is optionally alkylated or alkoxyated and has 4 to 30 ring atoms.

8. Polymer according to one or more of claims 1 to 7, which is selected from the group consisting of the following subformulae:

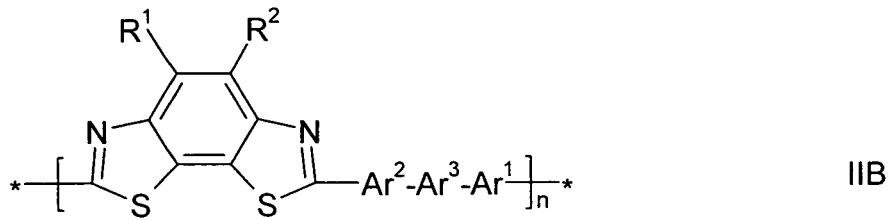
30



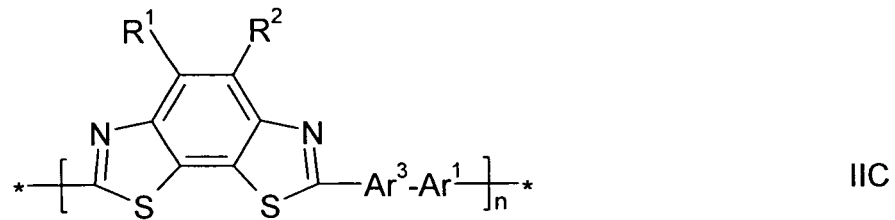
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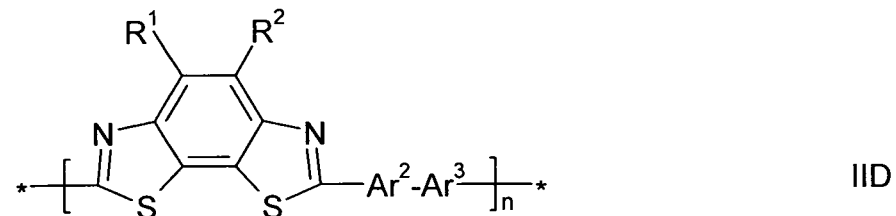
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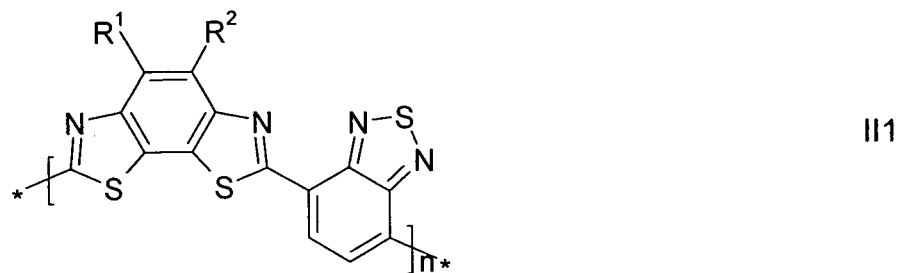


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wherein R^1 , R^2 , Ar^1 , Ar^2 , Ar^3 and n have the meanings given in one or more of claims 1 to 7, and wherein Ar^1 , Ar^2 and Ar^3 do not denote a single bond.

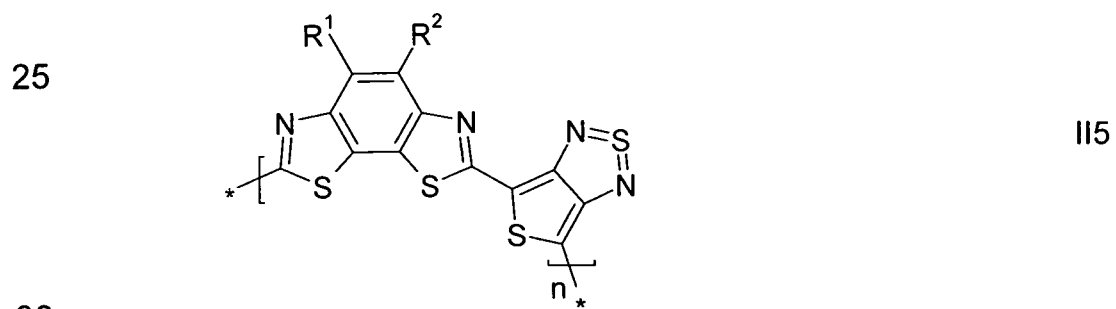
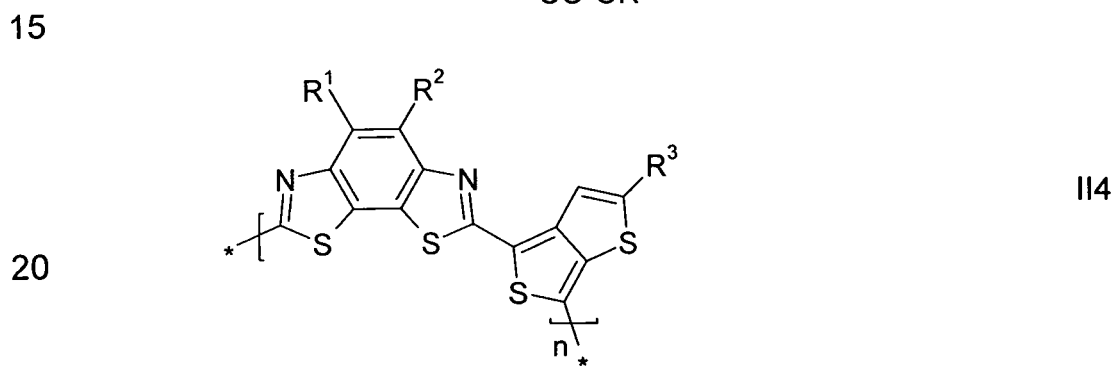
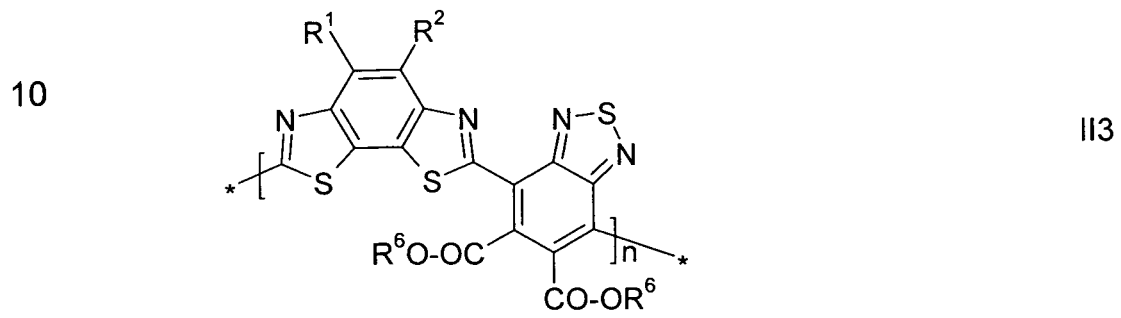
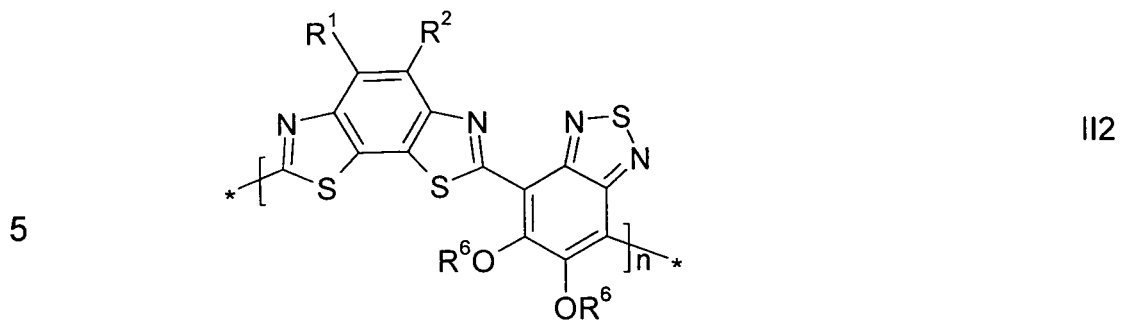
9. Polymer according to one or more of claims 1 to 8, which is selected from the group consisting of the following subformulae:

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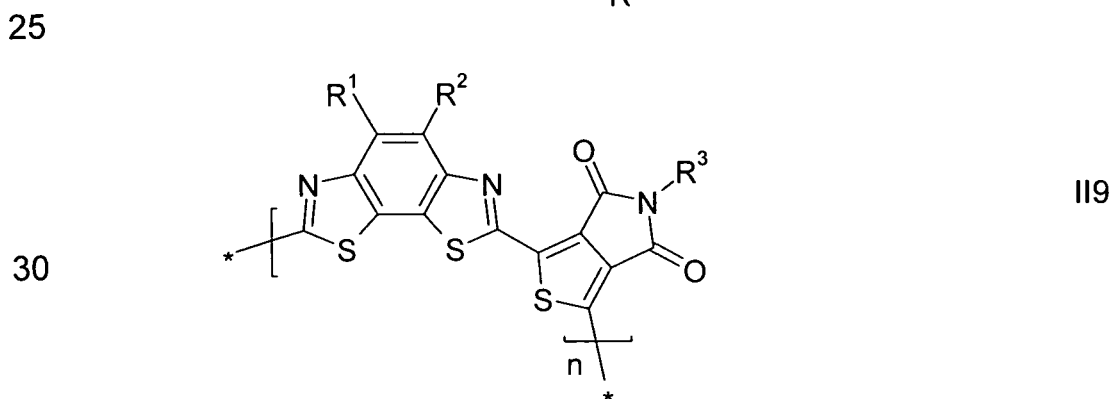
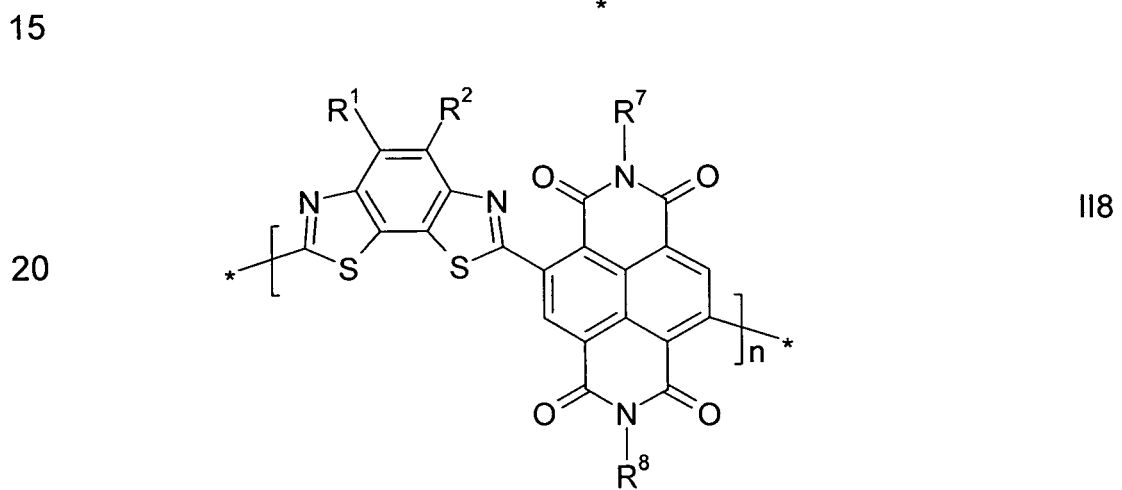
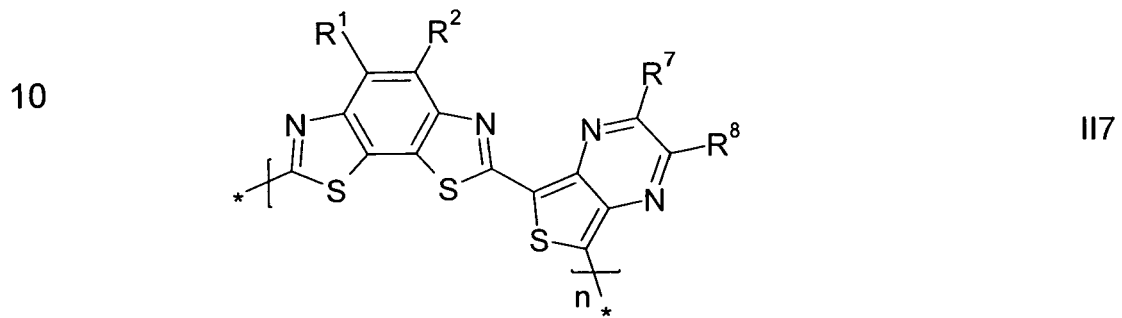
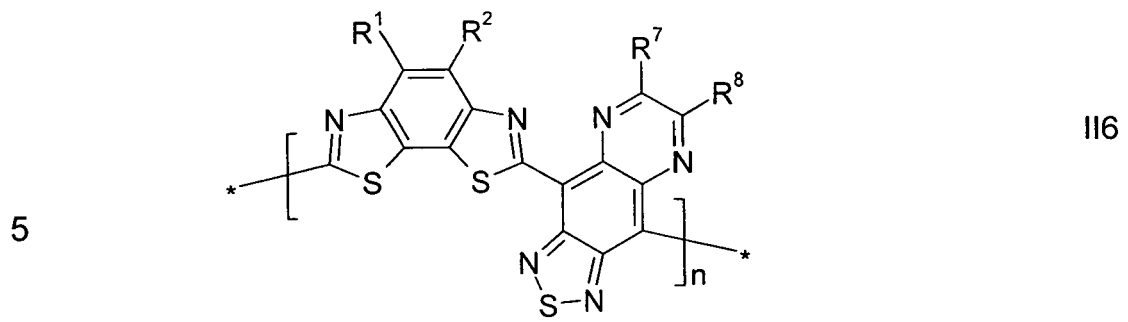


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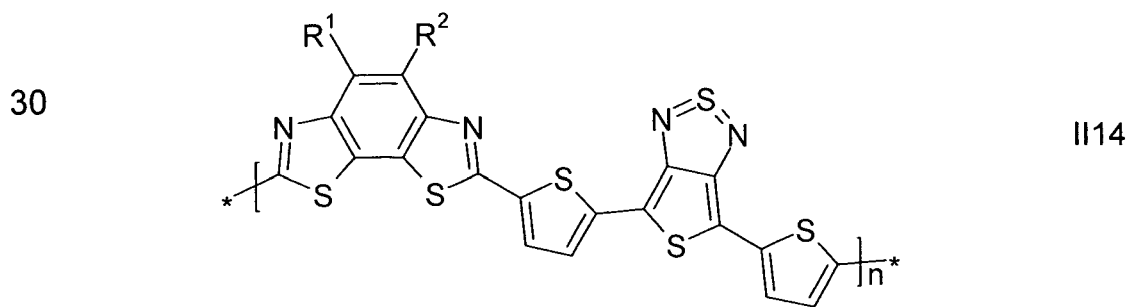
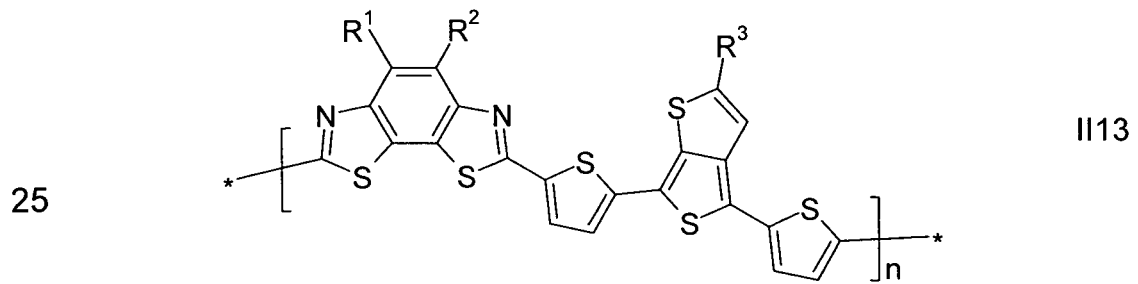
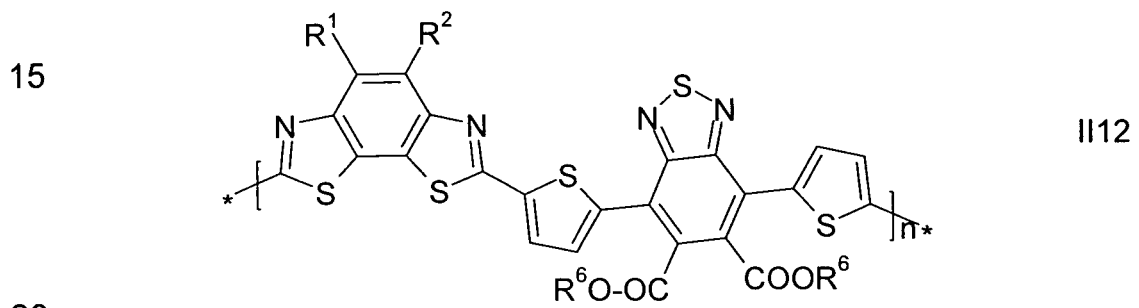
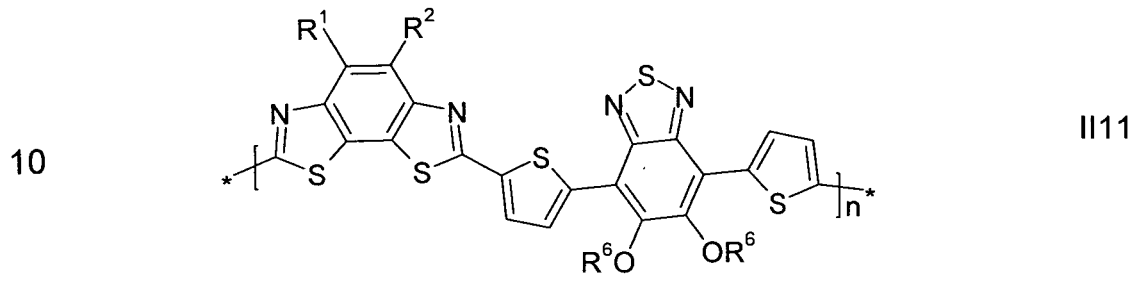
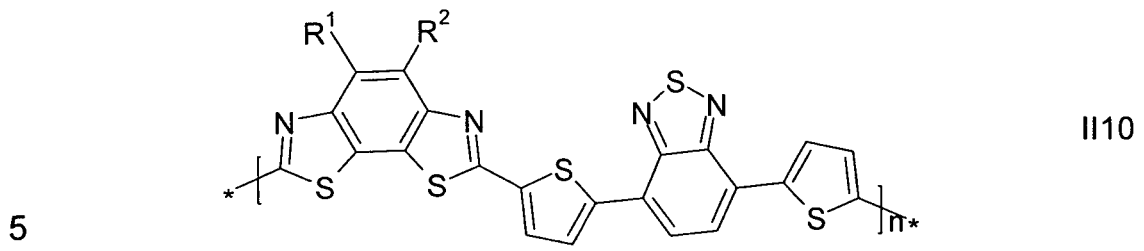
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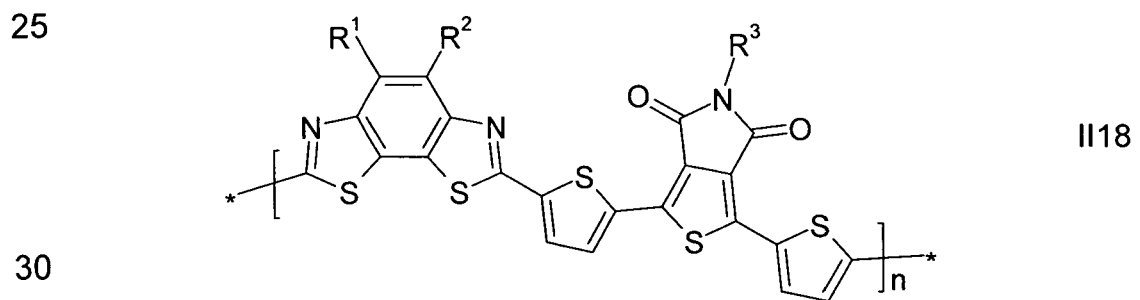
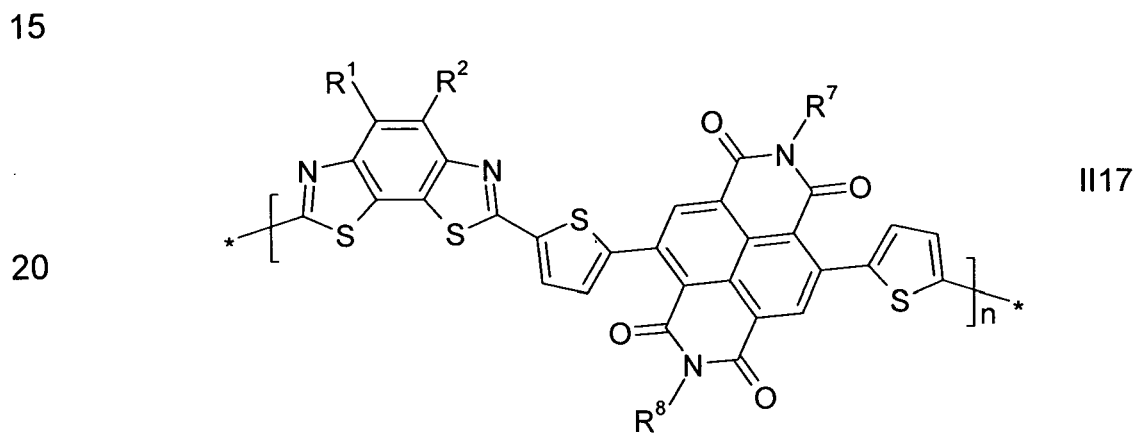
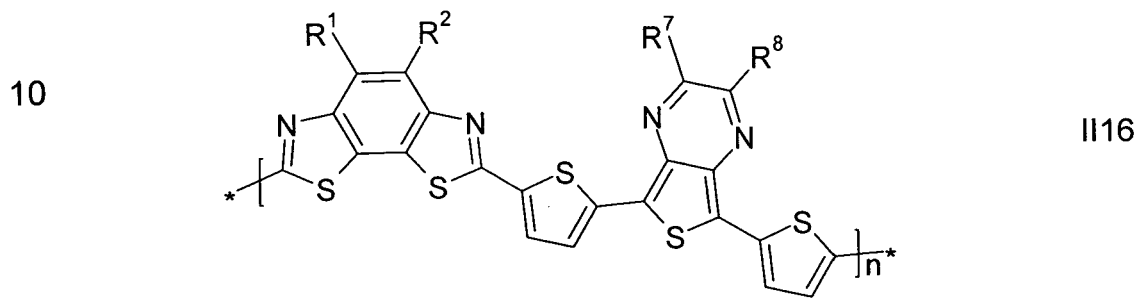
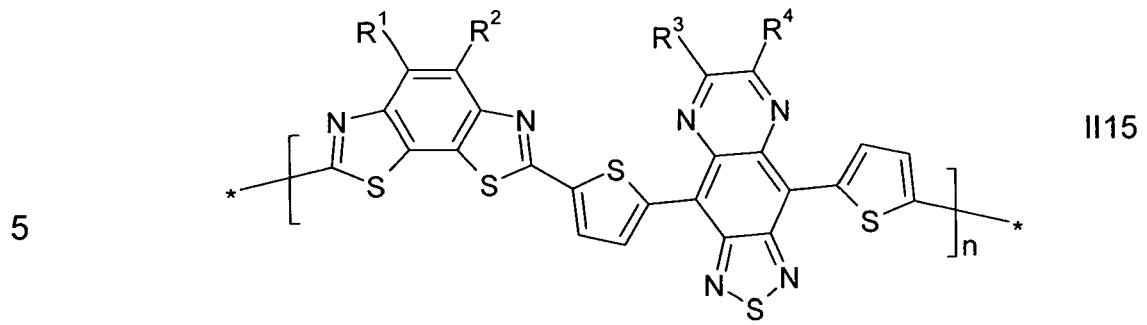


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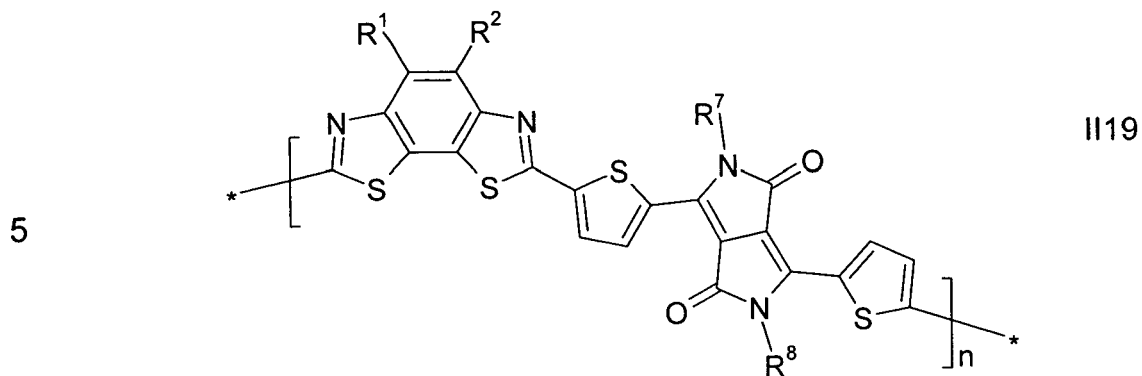


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10 wherein R^1 , R^2 , R^3 , R^6 and n have one of the meanings given in one or more of claims 1 to 8, and R^7 and R^8 have independently of each other one of the meanings of R^3 .

10. Polymer of the formula
- 15 R^4 -chain- R^5
- wherein "chain" is a polymer chain selected from formulae IIA-IIID and II1-II19 as defined in claim 8 or 9, and R^4 and R^5 have one of the meanings given in claim 4.
- 20 11. Mixture or blend comprising one or more polymers according to one or more of claims 1 to 10 and one or more compounds or polymers having semiconducting, charge transport, hole/electron transport, hole/electron blocking, electrically conducting, photoconducting or light emitting properties.
- 25 12. Formulation comprising one or more polymers, mixtures or blends according to one or more of claims 1 to 11, and one or more solvents, preferably selected from organic solvents.
- 30 13. Use of a polymer, mixture, blend or formulation according to one or more of claims 1 to 12 as charge transport, semiconducting, electrically conducting, photoconducting or light emitting material in optical, electrooptical, electronic, electroluminescent or photoluminescent components or devices.
- 35 14. Optical, electrooptical or electronic component or device comprising

one or more polymers, mixtures, blends or formulations according to one or more of claims 1 to 12.

- 5 15. Component or device according to claim 14, which is selected from the group consisting of organic field effect transistors (OFET), thin film transistors (TFT), integrated circuits (IC), logic circuits, capacitors, radio frequency identification (RFID) tags, devices or components, organic light emitting diodes (OLED), organic light emitting transistors (OLET), flat panel displays, backlights of displays, organic
- 10 photovoltaic devices (OPV), solar cells, laser diodes, photoconductors, photodetectors, electrophotographic devices, electrophotographic recording devices, organic memory devices, sensor devices, charge injection layers, charge transport layers or interlayers in polymer light emitting diodes (PLEDs), Schottky diodes,
- 15 planarising layers, antistatic films, polymer electrolyte membranes (PEM), conducting substrates, conducting patterns, electrode materials in batteries, alignment layers, biosensors, biochips, security markings, security devices, and components or devices for detecting and discriminating DNA sequences.

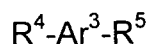
- 20 16. Component or device according to claim 14 or 15, which is an OFET or a bulk heterojunction OPV device.

- 25 17. Monomer of formula Ia



wherein U, Ar¹, Ar², R⁴ and R⁵ are as defined in one or more of claims 3 to 6.

- 30 18. Process of preparing a polymer according to one or more of claims 1 to 10, by coupling one or more monomers according to claim 17 with each other, and/or with one or more monomers of the formula



- 35 wherein R⁴, R⁵ and Ar³ are as defined in one or more of claims 3 to 6, in an aryl-aryl coupling reaction.